

aerospace
climate control
electromechanical
filtration
fluid & gas handling
hydraulics
pneumatics
process control
sealing & shielding





Microfiltration Products

For the Microelectronics Industry







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This document and other information from Parker Hannifin Corporation, its subsidiaries and authorized distributors provide product and/or system options for further investigation by users having technical expertise. It is important that you analyze all aspects of your application and review the information concerning the product or system in the current product catalog. Due to the variety of operating conditions and applications for these products or systems, the user, through its own analysis and testing, is solely responsible for making the final selection for the products and systems and assuring that all performance, safety and warning requirements of the application are met.

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Parker Hannifin

Leader in process filtration, separation and purification

2007

With sales offices in 26 countries, distribution channels active in 63 countries, and manufacturing operations in 6 countries, Parker specializes in providing filtration and separation products to a wide variety of markets including the microelectronics, pharmaceutical, food and beverage, manufacturing, automotive, oil and gas, and defense industries.

Manufacturing Excellence

Parker Hannifin Corporation is committed to manufacturing excellence.

Our state-of-the-art manufacturing facility features:

- A fully equipped laboratory and testing center
- Certified controlled cleanroom environments



Quality Management and ISO 9001

Quality is of paramount importance to Parker Advanced Filtration. All products are manufactured under controlled environmental conditions and are subjected to demanding programs of quality assurance.

Parker Hannifin Corporation Filtration is ISO 9001 certified.

Outline History

1984	All-fluoropolymer filter cartridges
1987	All-polypropylene depth cartridges for economical prefiltration
1994	Hydrophilic polyethersulfone (PES) membrane for liquid filtration applications
1994	Hydrophobic PTFE membrane filters for general purpose gas and solvent purification
1997	PTFE membrane filters with HDPE structure to maintain chemical purity
1998	Encapsulated all-fluoropolymer cartridge for aggressive chemical filtration
2003	SELECT pleat technology: optimizing effective filtration area to provide doubled lifetime
2005	Ultraclean technology: leading the industry in cleanliness offering filtration products with <5ppb metals extractables level
2005	Acquired by Parker Hannifin Corporation
2006	XF technology: provides superior flow rates

XL technology: new standard for flow and lifetime



Microelectronics:

A Core Expertise

The microelectronics industry is a rapidly growing world market that draws upon core areas of our filtration expertise. Included within this market are the broad range of electronics products that require highly effective filtration in their manufacturing processes.

These products include:

- semiconductors
- · flat panel displays
- · hard disk drives

Through our Technical, R&D and Customer Service teams we offer a wide range of services to ensure total customer satisfaction.

Technical Capabilities

Our Technical Services team is dedicated to the needs of the microelectronics industry. We have an extensive range of state-of-the-art analytical instrumentation and a highly qualified team of scientists and engineers generating innovative solutions to a wide variety of filtration needs. We strive to optimize our customers' filtration applications by offering full technical support that includes:

- · process failure analyses
- contamination analyses
- process and cost improvement audits
- · on-site testing services



Research and Development

Our R&D teams are constantly working to innovate new products and discover technologies that will enhance the performance of process filtration, and thus keep us at the forefront of process filtration technology.

Customer Service

An experienced team of professionals dedicated to respond quickly and comprehensively to orders - both for standard and customized products – and ensure their on-time delivery worldwide.



Microelectronics:

Applications



In the microelectronics Industry, filter process fall into three categories:

Chemical Filtration

- Etching
 Si etch (HF/HN03/
 Acetic Acid)
 SiO2 etch
 (BOE/BHF-HF/NH4F)
 Si3N4 etch
 (Hot H3PO4 up to 180°C)
 Al etch
 (H3PO4/HNO3/Acetic Acid)
- Stripping
 Hydroxy/amino based
 Glycol/NH4F based
 DMSO/amino based
- Cleaning
 Piranha (hot H2SO4/H2O2
 up to 150°C)
 SC1 (NH4OH/H202/H2O
 up to 90°C)
 SC2 (HCL/H2O2/H2O
 up to 90°C)
- Bulk chemical distribution

Photochemical Filtration

- Photoresist applications I-line, g-line and DUV 248/193nm)
- Anit-reflective coating applications (BARC/TARC)
- Solvent/Developing (<3% TMAH 97%H20)

Chemical Mechanical Planarization (CMP)

- Oxide
- Metal

Moore's Law

40 years ago, Intel co-founder Gordon Moore issued a famous analysis that proposed the number of transistors on an integrated circuit (IC) doubled every 18 months. This analysis (often referred to as Moore's law) still holds true today. The number of transistors per chip now runs into the billions with line-widths <100 nanometers.

The Microelectronics Market

Microelectronics are found everywhere from consumer electronics to satellites, from corporate data centers to microwave ovens.

The Microelectronics market is fast-paced and cyclical, driven by the constant demand to supply new products that are ever faster, with higher capacities and smaller footprints.

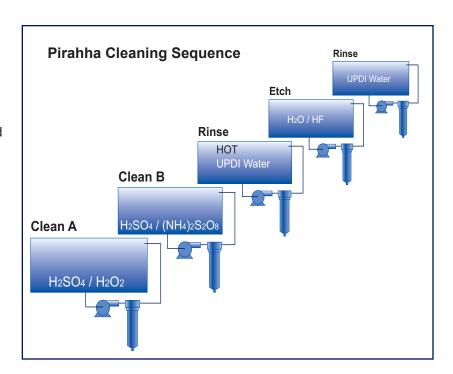
The manufacturing of the newest generations of IC chips would not be possible without effective filtration.

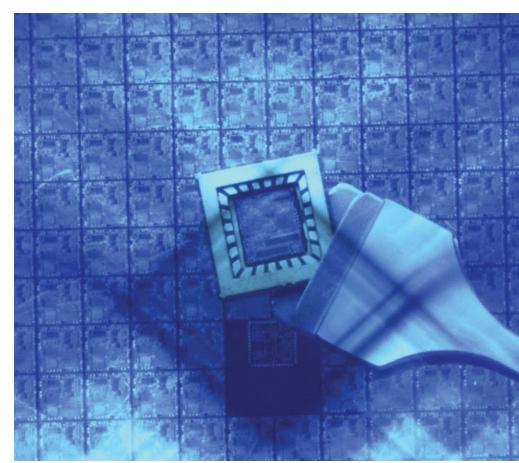
Semiconductors:

The filters used in semiconductor production processes need to provide the lowest possible levels of metals extractables and high particle retention efficiencies. However, since these processes combine the use of aggressive chemicals and high process temperatures, we have developed a wide range of fluoropolymer filters that possess high chemical and thermal resistance and are suited for all processes in the manufacturing of semiconductors.

Our fluoropolymer filters are available with the following options:

- XL: New standard for lifetime and flow rate
- SELECT high surface area and flow rates
- Ultraclean <5ppb metals extractables
- Wet-packed
- Capsules
- High particle retention efficiencies





Hard Disk Media

Crucial to the manufacture of disk media is the nickel-plating of the disks. This process is highly sensitive to both chemistry changes and interactions, and to contamination from high metallic dirt loadings. Understanding the plating requirements in the different parts of this process, we offer various ranges of filters:

Fluoroflow: fluoropolymer filters suitable for the aggressive chemical environment found in the plating process

Fluoroflow SELECT: a high-flow version of Fluoroflow with longer life

Clariflow: polyethersulfone membrane filters that provide extremely high bath recovery rates during disk cleaning

Clariflow SELECT: a high-flow version of Clariflow with longer life. All products enable high product yields and low reject rates, allowing for the lowest CPU (cost per unit).







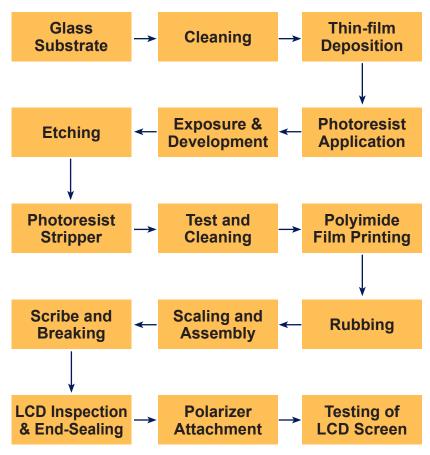
In the production of flat panel displays, the highest priority is to remove particulate contamination from process chemicals, including a wide variety of photoresists, developers, etchants and other chemical strippers.

To ensure consistent chemistry across all these chemistries, we offer ranges of filters that combine high flow capacities with high particle reduction efficiencies:

Polyflow:

polypropylene depth media **Polyflow membrane:** polypropylene membrane **Proflow:** PTFE membrane

Flat Panel Displays



Microfiltration Products

Engineered for Microelectronic Applications

At Parker we see every microelectronics application as an opportunity to provide a total filtration solution. We have this capability due to our constant drive to be at the leading edge of filtration technology. Our innovative engineering teams work closely with our dedicated worldwide support network resulting in unparalleled customer satisfaction.









FLUOROCAP® 100% Fluoropolymer capsules

CHEMFLOW® PE PTFE Membrane / High Density Polyethylene construction

CLARIFLOW® Polyethersulfone (PES) Membrane / Polypropylene construction

PROFLOW II® PTFE Membrane / Polypropylene construction

POLYFLOW® MEMBRANE Polypropylene Membrane / Polypropylene construction

POLYFLOW®

Polypropylene absolute – and nominal-rated depth media Polypropylene structure

A wide variety of housings is available. Contact your Parker Filtration Sales Representative for more details.







Parker offers a wide range of microfiltration products for critical liquid and gas applications, with particle removal ratings from 0.02 to 40 micron.

Our products will consistently meet your exacting performance and compatibility requirements – even in processes using aggressive chemicals. Our products can offer metal extractables <5ppb.



Microfiltration Products

Engineered for Microelectronic Applications

Product line	Available Configurations	Filter Ratings (microns)	SELECT* and Ultraclean	Typical Applications
FLUOROFLOW® 100% Fluoropolymer Construction	Cartridge	0.03, 0.05, 0.1, 0.2, 0.45, 1	S U	 Critical filtration of aggressive acids, bases, strippers, and solvents Available for high temperature applications
FLUOROCAP® 100% Fluoropolymer Construction Capsules	Capsule	0.03, 0.05, 0.1, 0.2	S U	 Encapsulated filter for critical filtration of aggressive chemicals and process fluids under harsh conditions where the introduction of contamination during cartridge change out is a concern Available for high temperature applications
CHEMFLOW® PE PTFE Membrane / High Density Polyethylene Structure	Cartridge	0.03, 0.05, 0.1, 0.2, 1	S	 Purification of photoresists, chemicals and etch baths Filtration of solvents, cleaning solutions
CLARIFLOW® Polyethersulfone (PES) Membrane / Mini Polypropylene Structure	Cartridge Mini-Capsule Mini-Cartridge	0.02, 0.04, 0.1, 0.2, 0.45, 0.65, 0.8	S	Aqueous based chemicals; recirculating etch baths; UPW systems
PROFLOW II® PTFE Membrane / Polypropylene / Mini Structure	Cartridge Mini-Capsule Mini-Cartridge	0.03, 0.05, 0.1, 0.2, 0.45, 1	S	 Ultrapure chemicals and gas processing; photochemical processing Bulk chemical distribution
POLYFLOW® MEMBRANE Polypropylene Nominal Rated Membrane / Polypropylene Structure	Cartridge	0.04, 0.07, 0.1, 0.2	S	Filtration of photochemicals and ultrapure chemicalsGas filtration
POLYFLOW® Polypropylene Absolute Rated Depth Media / Polypropylene Structure *Patent pending	Cartridge Mini-Capsule Mini-Cartridge	0.6, 1.2, 2.5, 5, 10, 20, 40		DI water prefiltrationSolvent and gas prefiltrationGeneral filtration







- The revolutionary SELECT technology filter cartridges can improve and lower the costs of wafer processing. Imagine: up to 80% more effective filtration area with twice the throughput. All of this with a particle retention of >99.99% from a product that is cleanroom manufactured and tested.
- XL technology provides maximum flow rate and lifetime. It combines SELECT technology with a larger diameter cartridge (3.25") for the highest flows in the industry.
- Ultraclean technology leads the microelectronics industry in cleanliness. Ultraclean is a proprietary process applied to electronics grade products. It provides a total metals extractables level of <5ppb. Ultraclean's low level of metals extractables provides users with a highly consistent manufacturing process and very low product reject

Parker Hannifin Corporation is committed to provide the highest quality product to our customers. To this end, our ISO 9001 certified Quality System ensures that this occurs. At Parker Hannifin Corporation, we do our best to resolve all quality issues in a quick and timely manner. In addition, we strive to eliminate problems before they are seen. By taking this continuously proactive approach to the quality of all of our products, Parker Hannifin Corporation has the best product on the market at all times.



Fluoroflow®

All-fluoropolymer cartridge for aggressive applications

The Fluoroflow® filter cartridge is our standard product for aggressive wet etch and clean applications. It provides good flow rates and on-stream life at an economical cost. The all-fluoropolymer construction provides excellent chemical resistance for the most aggressive applications up to 150°C. It is available either ozone DI flushed and dried or wet-packed for quick installation.



Benefits

- Economical
- Wet-pack option for guick installation
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested for consistent quality

Applications

- · Wet etch and clean
 - Phosphoric acid
 - Sulfuric acid
 - Hydrofluoric acid
 - Nitric acid
 - Piranha
 - SC1,SC2
 - NMP-based solvents
- Other high temperature or ozonated processes

Parker Hannifin Corporation provides our customers with unsurpassed product consistency and cost-efficiency.

Our experienced professionals can help you select the right solution for your application. For more information or to place an order, contact your local distributor. Information on product specifications, applications and chemical compatibility can be found on our web site at www.parker.com or through your nearest Parker Hannifin Corporation office.

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Fluoroflow®

Specifications

Materials of Construction

100% Fluoropolymer construction

Effective Filtration Area

6.8ft² (0.63m²) per nominal 10" (250mm) cartridge

Metals Extractables*

Standard: <20ppb (total) Ultraclean: <5ppb (total) *in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward 80psid (5.5bar) @ 75°F (24°C)

55psid (3.8bar) @ 167°F (75°C) 30psid (2.0bar) @ 257°F (125°C)

15psid (1.0bar) @ 300°F (150°C)

Reverse 50psid (3.4bar) @ 75°F (24°C)

15psid (1.0bar) @ 250°F (121°C)

Cleanliness (particle shedding)

Wet-packed <2 particles/ml >0.2µm after

7gal at 1gal/min

TOC/Resistivity Rinse-up (wet-packed)

TOC recovery within 3-5ppb of feed without additional rinse-up. Resistivity recovery within 0.4megohm-cm of feed after 22gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

 0.05μm
 0.9gpm/psid (4.9lpm/100mbar)

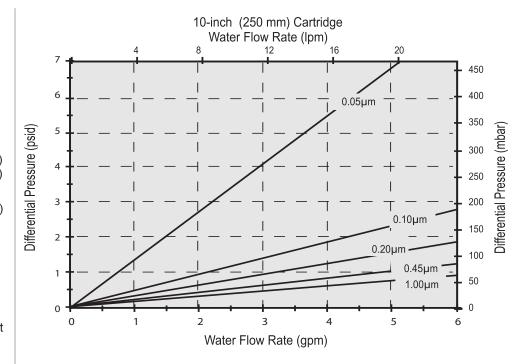
 0.10μm
 2.3gpm/psid (12.7lpm/100mbar)

 0.20μm
 3.2gpm/psid (17.6lpm/100mbar)

 0.45μm
 4.7gpm/psid (25.8lpm/100mbar)

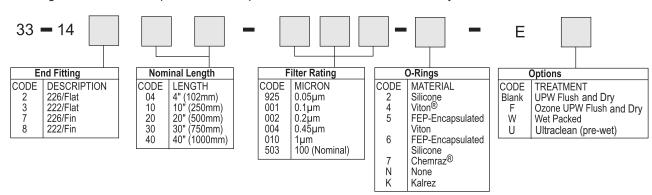
 1.00μm
 6.7gpm/psid (36.9lpm/100mbar)

*Per 10" (250mm) cartridge equivalent



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Fluoroflow®-HSA

Increased performance all-fluoropolymer cartridge for aggressive applications

The Fluoroflow®-HSA filter cartridge provides good flow rates and on-stream life. The enhanced pleating provides more than 40% more surface area than our standard Fluoroflow®. This results in increased bath turnover and longer filter lifetime demanded by today's fabs. The all-fluoropolymer construction provides excellent chemical resistance for the most aggressive applications up to 180°C. Available wet-packed for quick installation or Ultraclean wet-packed which offers the lowest metals extractables in the industry.



Benefits

- · Increased filtration area for longer life
- Higher flow rates for increased bath turn over
- Wet-pack option for quick installation
- Ultraclean wet-pack option for absolute cleanliness
- All-fluoropolymer for most maximum chemical resistance
- 100% integrity tested for consistent quality

Applications

- · Wet etch and clean
 - Phosphoric acid
 - Sulfuric acid
 - Hydrofluoric acid
 - Nitric acid
 - Piranha
 - SC1,SC2
 - NMP-based solvents
- Other high temperature or ozonated processes

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Fluoroflow®-HSA

Specifications

Materials of Construction

100% Fluoropolymer construction
All components are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area

4.8ft² (0.45 m²) 4" (100mm) cartridge 9.8ft² (0.91 m²) 10" (250mm) cartridge

Metals Extractables*

Standard: <20ppb (total) Ultraclean: <5ppb (total) *in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C) 55psid (3.8bar) @ 167°F (75°C) 30psid (2.0bar) @ 257°F (125°C)

15psid (1.0bar) @ 300°F (150°C)

Forward

HT option: 100psid (6.8bar) @ 75°F (24°C)

75psid (5.1bar) @ 167°F (75°C) 50psid (3.4bar) @ 257°F (125°C) 15psid (1.0bar) @ 356°F (180°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

15psid (1.0bar) @ 250°F (121°C)

Cleanliness (particle shedding)

Wet-packed: <2 particles/ml >0.2µm after

7gal at 1gpm

TOC/Resistivity Rinse-up (wet-packed)

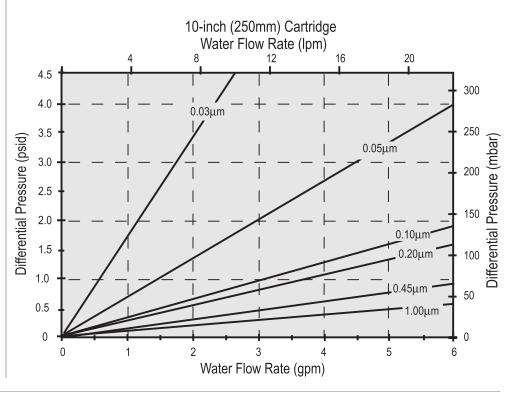
TOC recovery within 3-5ppb of feed without additional rinse-up. Resistivity recovery within 0.4megohm-cm of feed after 22gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

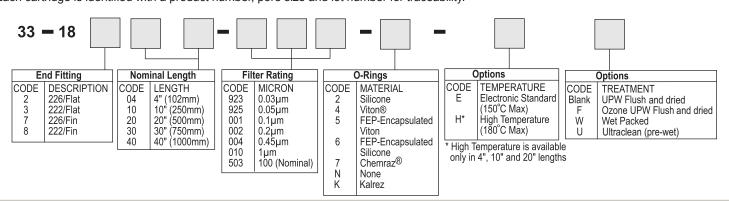
0.03μm
 0.65gpm/psid (3.6lpm/100 mbar)
 0.05μm
 1.5gpm/psid (8.2lpm/100 mbar)
 0.10μm
 3.2gpm/psid (17.6lpm/100 mbar)
 0.20μm
 3.9gpm/psid (21.5lpm/100 mbar)
 0.45μm
 1.00μm
 10.0gpm/psid (55.0lpm/100 mbar)

*Per 10" (250mm) cartridge equivalent



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Chemraz is a registered trademark of Green, Tweed Inc.

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Fluoroflow®-Select

High performance all-fluoropolymer cartridge for aggressive applications

The Fluoroflow®-SELECT filter cartridge provides exceptional flow rates and on-stream life. It utilizes our unique SELECT pleating technology that increases filtration area and flow rate by over 70% versus our standard Fluoroflow®. This results in increased bath turnover and longer filter lifetime demanded by today's fabs. The all-fluoropolymer construction provides excellent chemical resistance for the most aggressive applications up to 180°C. Available wet-packed for quick installation or Ultraclean wetpacked which offers the lowest metals extractables in the industry.



Benefits

- · Large filtration area for longer life
- High flow rates for increased bath turn over
- Wet-pack option for quick installation
- Ultraclean wet-pack option for absolute cleanliness
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested for consistent quality

Applications

- · Wet etch and clean
 - Phosphoric acid
 - Sulfuric acid
 - Hydrofluoric acid
 - Nitric acid
 - Piranha
 - SC1,SC2
 - NMP-based solvents
- Other high temperature or ozonated processes

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Fluoroflow®-Select

Specifications

Materials of Construction

100% Fluoropolymer construction

All components are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area

6.0ft² (0.56 m²) 4" (100mm) cartridge 12.2ft² (1.1 m²) 10" (250mm) cartridge

Metals Extractables*

Standard: <20ppb (total) Ultraclean: <5ppb (total) *in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward 80psid (5.5bar) @ 75°F (24°C)

55psid (3.8bar) @ 167°F (75°C) 30psid (2.0bar) @ 257°F (125°C)

15psid (1.0bar) @ 300°F (150°C)

Forward

HT option 100psid (6.8bar) @ 75°F (24°C)

75psid (5.1bar) @ 167°F (75°C) 50psid (3.4bar) @ 257°F (125°C) 15psid (1.0bar) @ 356°F (180°C)

Reverse 50psid (3.4bar) @ 75°F (24°C)

15psid (1.0bar) @ 250°F (121°C)

Cleanliness (particle shedding)

Wet-packed <2 particles/ml >0.2µm after

7gal at 1gal/min

Dry-packed <2 particles/ml >0.2µm after

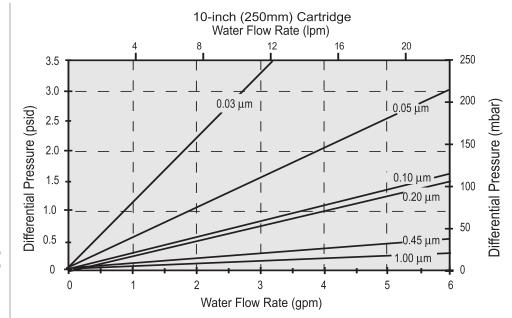
12gal at 1gal/min

Performance Attributes

Water Flow rates, Typical *

0.03μm
 0.85gpm/psid (4.7lpm/100mbar)
 0.05μm
 2.0gpm/psid (11.0lpm/100mbar)
 0.10μm
 4.1gpm/psid (22.6lpm/100mbar)
 0.20μm
 4.6gpm/psid (25.3lpm/100mbar)
 10.5gpm/psid (57.6lpm/100mbar)
 1.00μm
 16.0gpm/psid (87.8lpm/100mbar)

*Per 10" (250mm) cartridge equivalent



TOC/Resistivity Rinse-up (wet-packed)

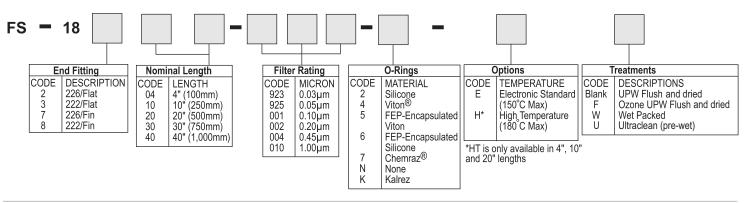
TOC recovery within 3-5ppb of feed without additional rinse-up.

Resistivity recovery within 0.4megohm-cm

of feed after 22gal @ 1gpm.

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Fluoroflow®-XL

Highest-performance all-fluoropolymer cartridge for aggressive applications

The Fluoroflow®-XL filter cartridge is setting the new standard for exceptional flow rates and on-stream life. It utilizes a larger diameter cartridge (3.25") combined with our unique SELECT pleating technology that increases filtration area and flow rate by over 70%. This results in increased bath turnover and longer filter lifetime demanded by today's advanced 300mm fabs. The all-fluoropolymer construction provides excellent chemical resistance for the most aggressive applications up to 180°C. Its integral filter design maximizes up-time with safe and simple change-outs. Available wet-packed for quick installation or Ultraclean wet-packed which offers the lowest metals extractables in the industry.



Benefits

- Extra large filtration area for longer life
- Highest flow rates for maximum bath turn over
- Wet-pack option for quick installation
- Ultraclean option for absolute cleanliness
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested for consistent quality

Applications

- · Wet etch and clean
 - Phosphoric acid
 - Sulfuric acid
 - Hydrofluoric acid
 - Nitric acid
 - Piranha
 - SC1,SC2
 - NMP-based solvents
- Other high temperature or ozonated processes

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Fluoroflow®-XL

Specifications

Materials of Construction

100% Fluoropolymer construct

All components are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area per 10" (250mm) Cartridge

22.5ft² (2.04 m²) 0.03µm 21.5ft² (1.99 m²) 0.05µm 18.5ft² (1.71 m²) 0.10µm

Metals Extractables*

Standard: <30ppb (total) Ultraclean: <7ppb (total) *in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward: 70psid (5.5bar) @ 75°F (24°C)

50psid (3.8bar) @ 167°F (75°C) 30psid (2.0bar) @ 257°F (125°C) 15psid (1.0bar) @ 300°F (150°C)

Forward

HT option: 15psid (1.0bar) @356°F (180°C) Reverse: 50psid (3.4bar) @ 75°F (24°C)

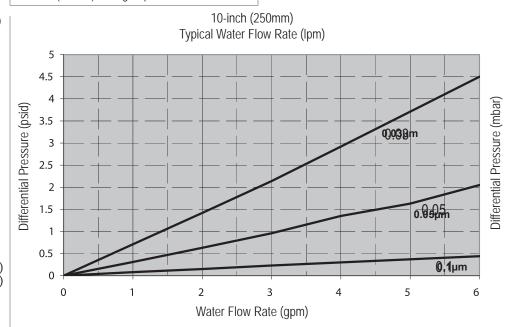
15psid (1.0bar) @ 250°F (121°C)

Performance Attributes

Water Flow rates, Typical *

0.03μm
 0.05μm
 0.10μm
 1.4gpm/psid (7.7lpm/100mbar)
 3.3gpm/psid (18.2lpm/100mbar)
 13.0gpm/psid (71.3lpm/100mbar)

*Per 10" (250mm) cartridge equivalent



Cleanliness (particle shedding)

Wet-packed: <2 particles/ml >0.2µm after

7gal at 1gpm

Dry-packed: <2 particles/ml >0.2µm after

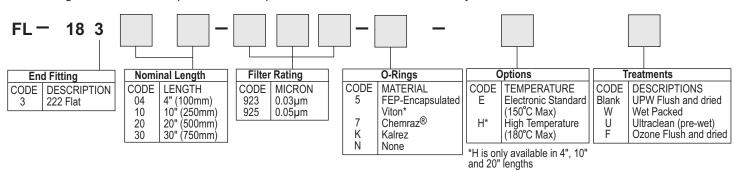
12gal at 1gpm

TOC/Resistivity Rinse-up (wet-packed)

TOC recovery within 3-5ppb of feed without additional rinse-up. Resistivity recovery within 0.4megohm-cm of feed after 22gal @ 1gpm.

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Fluorocap[®]

All-fluoropolymer capsule for the most aggressive applications

The Fluorocap® encapsulated filter cartridge is our standard product for aggressive wet etch and clean applications. It provides good flow rates and on-stream life at an economical price. The all-fluoropolymer construction provides excellent chemical resistance for the most aggressive applications up to 180°C. Its integral filter design maximizes up-time with safe and simple changeouts. Available wet-packed for quick installation or Ultraclean wet-packed which offers the lowest metals extractables in the industry.



Benefits

- Economical
- Wide range of configurations and ratings
- Wet-pack option for quick installation
- Ultraclean option for absolute cleanliness
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested for consistent quality

Applications

- · Wet etch and clean
 - Hot phosphoric acid
 - Sulfuric acid
 - Hydrofluoric acid
 - Nitric acid
 - Piranha
 - SC1,SC2
 - NMP-based solvents
- Other high temperature or ozonated processes

Parker Hannifin Corporation provides our customers with unsurpassed product consistency and cost-efficiency.

Our experienced professionals can help you select the right solution for your application. For more information or to place an order, contact your local distributor. Information on product specifications, applications and chemical compatibility can be found on our web site at www.parker.com or through your nearest Parker Hannifin Corporation office.

Parker Hannifin Corporation designs and manufactures an extensive line of innovative solutions for specific applications in the Microelectronics, Biopharmaceutical, Food and Beverage, Industrial and Chemical industries.



Fluorocap®

Specifications

Materials of Construction

100% Fluoropolymer construction All components are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area

9.8 ft² (0.9m²) per 10" filter length

Metals Extractables*

Standard: <20ppb (total) Ultraclean: <5ppb (total) *in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C) Standard: 55psid (3.8bar) @ 167°F (75°C) 30psid (2.0bar) @ 257°F (125°C)

15psid (1.0bar) @ 300°F (150°C)

Forward: 100psid (6.8bar) @ 75°F (24°C) HT Option: 75psid (5.1bar) @ 167°F (75°C)

50psid (3.4bar) @ 257°F (125°C) 15psid (1.0bar) @ 356°F (180°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

15psid (1.0bar) @ 250°F (121°C)

Performance Attributes

Water Flow rates, Typical*

0.03μm
 0.65gpm/psid (3.3lpm/100mbar)
 0.05μm
 1.5gpm/psid (8.2lpm/100mbar)
 0.10μm
 3.2gpm/psid (17.6lpm/100mbar)
 0.20μm
 4.1gpm/psid (22.5lpm/100mbar)
 0.45μm
 6.6gpm/psid (36.2lpm/100mbar)
 1.00μm
 8.9gpm/psid (49.0lpm/100mbar)

*Flow rates are for in-line Fluorocaps with 3/4" Parflare fittings.

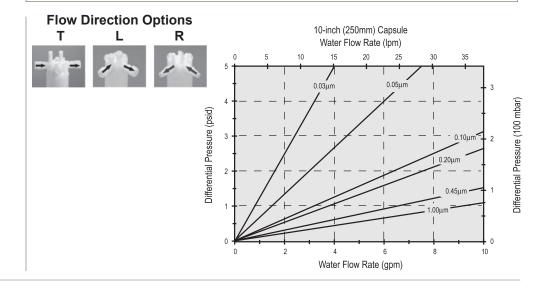
Cleanliness (particle shedding)

Wet-packed: <2 particles/ml >0.2µm after

7gal at 1gpm

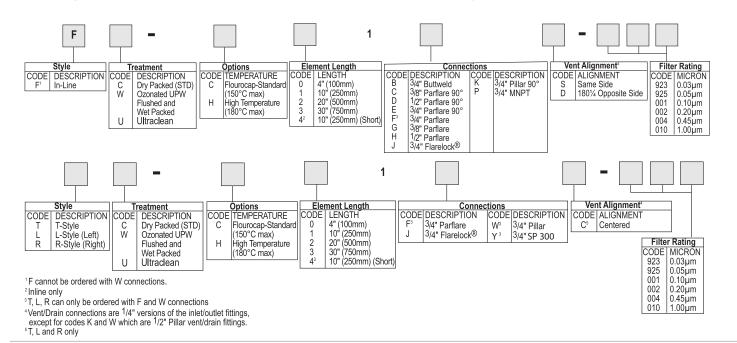
TOC/Resistivity Rinse-up (wet-packed)

TOC recovery within 3-5ppb of feed after 12gal @ 1gpm. Resistivity recovery within 0.4megohm-cm of feed after 22gal @ 1gpm



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Fluorocap®-Select

High performance all-fluoropolymer capsule for the most aggressive applications

The Fluorocap®-SELECT encapsulated filter cartridge provides exceptional flow rates and on-stream life. It utilizes our unique SELECT pleating that increases filtration area and flow by over 25% compared to our standard Fluorocap®. This results in increased bath turnover and longer filter lifetime demanded by today's fabs. The all-fluoropolymer construction provides excellent chemical resistance for the most aggressive applications up to 180°C. Its integral filter design maximizes up-time with safe and simple changeouts. Available wet-packed for quick installation or Ultraclean wet-packed which offers the lowest metals extractables in the industry.



Benefits

- · Large filtration area for longer life
- High flow rates for maximum bath turn over
- Wet-pack option for quick installation
- Ultraclean option for absolute cleanliness
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested for consistent quality

Applications

- · Wet etch and clean
 - Hot phosphoric acid
 - Sulfuric acid
 - Hydrofluoric acid
 - Nitric acid
 - Piranha
 - SC1,SC2
 - NMP-based solvents
- Other high temperature or ozonated processes

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Fluorocap®-Select

Specifications

Materials of Construction

100% Fluoropolymer construction All components are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area

12.2 ft² (1.1m²) per 10" (250mm) for 0.03 & 0.05µm

11.4 ft² (1.0m²) per 10" (250mm) for other ratings

Metals Extractables*

Standard: <20ppb (total) Ultraclean: <5ppb (total) *in a 10% HNO3 extraction

Maximum Differential Pressure/Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

Standard: 55psid (3.8bar) @ 167°F (75°C) 30psid (2.0bar) @ 257°F (125°C)

15psid (1.0bar) @ 300°F (150°C)

Forward: 100psid (6.8bar) @ 75°F (24°C) HT Option: 75psid (5.1bar) @ 167°F (75°C)

50psid (3.4bar) @ 257°F (125°C) 15psid (1.0bar) @ 356°F (180°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

15psid (1.0bar) @ 250°F (121°C)

Performance Attributes

Water Flow rates, Typical *

0.03μm
 0.85gpm/psid (4.6lpm/100mbar)
 0.05μm
 2.0gpm/psid (11.0lpm/100mbar)
 0.10μm
 4.1gpm/psid (22.5lpm/100mbar)
 0.20μm
 4.6gpm/psid (25.3lpm/100mbar)
 0.45μm
 9.6gpm/psid (52.7lpm/100mbar)
 1.00μm
 14.8gpm/psid (81.3lpm/100mbar)

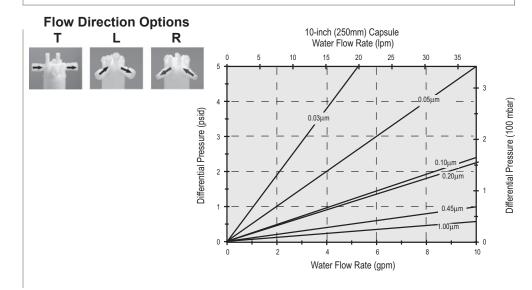
Cleanliness (particle shedding)

Wet-packed: 2 particles/ml >0.2µm after

7gal at 1gpm

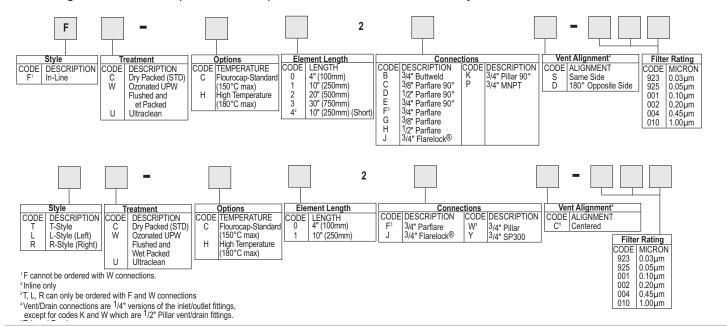
TOC/Resistivity Rinse-up (wet-packed)

TOC recovery within 3-5ppb of feed after 12gal @ 1gpm. Resistivity recovery within 0.4megohm-cm of feed after 22gal @ 1gpm



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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^{*} Flow rates shown are for FluoroCap filters with 3/4" Parflare™ (in-line) fittings.

Fluorocap®-XL

Highest-performance all-fluoropolymer capsule for the most aggressive applications

The Fluorocap®-XL encapsulated filter cartridge is setting the new standard for exceptional flow rates and on-stream life. It utilizes a larger diameter cartridge combined with our unique SELECT pleating that increases filtration area by over 70%. This results in increased bath turnover and longer filter lifetime demanded by today's advanced 300mm fabs. The all-fluoropolymer construction provides excellent chemical resistance for the most aggressive applications up to 180°C. Its integral filter design maximizes up-time with safe and simple change-outs. Available wetpacked for quick installation or Ultraclean wet-packed which offers the lowest metals extractables in the industry.



Benefits

- Extra large filtration area for longer life
- Highest flow rates for maximum bath turn over
- Wet-pack option for quick installation
- Ultraclean option for absolute cleanliness
- All-fluoropolymer for maximum chemical resistance
- 100% integrity tested for consistent quality

Applications

- · Wet etch and clean
 - Hot phosphoric acid
 - Sulfuric acid
 - Hydrofluoric acid
 - Nitric acid
 - Piranha
 - SC1, SC2
 - NMP-based solvents
- Other high temperature or ozonated processes

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Fluorocap®-XL

Specifications

Materials of Construction

100% Fluoropolymer construction All components are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area per 10" (250mm) Cartridge

22.5ft2 (2.04 m2) 0.03µm 21.5ft² (1.99 m²) 0.05µm 18.5ft² (1.71 m²) 0.10µm

Metals Extractables*

Standard: <30ppb (total) Ultraclean: <7ppb (total) *in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 75°F (24°C) Standard: 50psid (3.4bar) @ 167°F (75°C)

15psid (1.0bar) @ 300°F (150°C)

Forward

HT option: 15psid (1.0bar) @356°F (180°C) Reverse: 50psid (3.4bar) @ 75°F (24°C)

15psid (1.0bar) @ 250°F (121°C)

Performance Attributes

Water Flow rates, Typical *

0.03µm 1.2gpm/psid (6.6lpm/100mbar) 2.7gpm/psid (14.9lpm/100mbar) 0.05µm 6.5gpm/psid (35.8lpm/100mbar) 0.10µm

*Flow rates are for in-line Fluorocaps with 3/4" Parflare fittings.

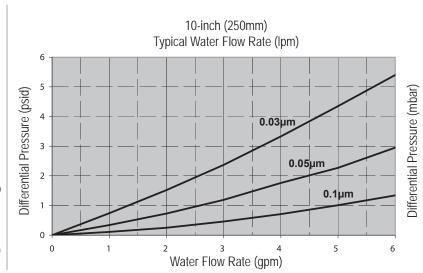
Cleanliness (particle shedding)

Wet-packed: <2 particles/ml >0.2µm after

7gal at 1gpm

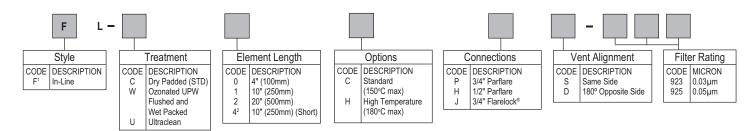
TOC/Resistivity Rinse-up (wet-packed)

TOC recovery within 3-5ppb of feed after 12gal @ 1gpm. Resistivity recovery within 0.4megohm-cm of feed after 22gal @ 1gpm.



Ordering Information

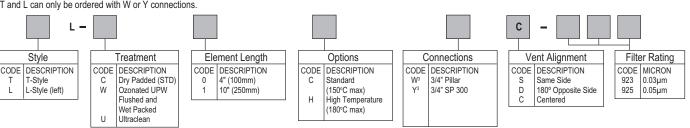
Each capsule is identified with a product number, pore size and lot number for traceability.



¹F cannot be ordered with W connections.

²Inline only.

³T and L can only be ordered with W or Y connections.



¹F cannot be ordered with W connections.

²Inline only.

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³T and L can only be ordered with W or Y connections.

Chemflow®-PE

Chemically-resistant cartridge for bulk and lower temperature applications

The Chemflow®-PE filter cartridge uses a PTFE membrane along with HDPE supports that provide an economical alternative to all-fluoropolymer cartridges. It provides a high degree of retention and cleanliness along with good flow and lifetime. This filter is ideally suited for bulk chemical delivery and lower temperature wet processes (<60°C). It is available dry or wetpacked for quick installation.



Benefits

- · Good flow rates
- · Long lifetime
- Wet-pack option for quick installation
- PTFE/ HDPE construction for chemical resistance
- 100% integrity tested in cleanroom environment

Applications

- · Bulk chemical delivery
 - Acids, bases, solvents, photochemicals
 - Wet etch and clean (< 60°C)
 - Phosphoric acid
 - Hydrofluoric acid
 - Nitric acid
 - SC1,SC2
 - Solvents

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Chemflow®-PE

Specifications

Materials of Construction

Membrane : PTFE Support Layers : HDPE Structure : HDPE

Effective Filtration Area

8.3ft² (0.78m²) per 10" (250mm) cartridge

Metals Extractables*

Standard: <55ppb (total)
*in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C) Reverse: 50psid (3.4bar) @ 75°F (24°C)

Maximum Operating Temperature

140°F (60°C)

Cleanliness (particle shedding)

Wet-packed: <1 particles/ml >0.2µm after

5gal at 1gpm

Data is from open bag and installed, no additional

installation flushing.

TOC/Resistivity Rinse-up (wet-packed)

TOC rinse-up to background plus 5ppb of feed after 70gal @ 1gpm. Resistivity rinse-up to background minus 0.2 megohm-cm of feed after 60gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

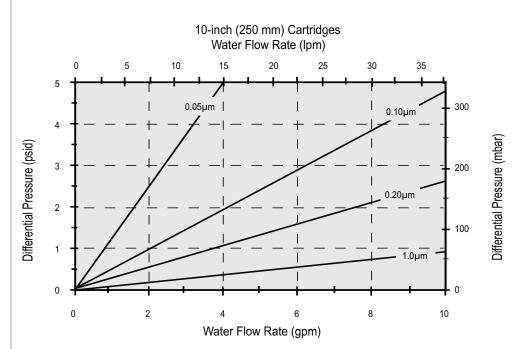
 0.05μm
 0.8gpm/psid (4.39lpm/100mbar)

 0.10μm
 2.1gpm/psid (11.53lpm/100mbar)

 0.20μm
 3.8gpm/psid (20.86lpm/100mbar)

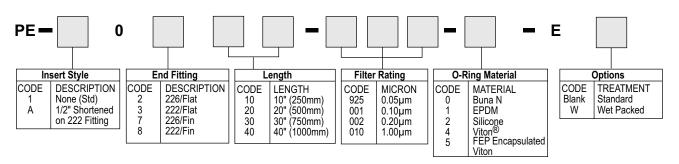
 1.0μm
 10gpm/psid (55.0lpm/100bar)

* Per 10-inch (250mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Proflow™ II-E

Chemically-resistant cartridge for ultrapure microelectronics fluids and gases

The Proflow™II-E filter cartridge uses a PTFE membrane along with high-purity polypropylene supports that provide an economical alternative to all-fluoropolymer cartridges. It provides a high degree of retention and cleanliness along with good flow and lifetime. This filter is ideally suited for ultrapure microelectronics fluids and gases. The hydrophobic PTFE membrane serves as a highly efficient barrier to insure low moisture content of gases. It is available dry or wet-packed for quick installation and lower extractables.



Benefits

- · Good liquid and gas flow rates
- · Wet-pack option for quick installation
- PTFE/ PP construction for chemical resistance
- Wide variety of configurations and ratings
- 100% integrity tested in cleanroom environment

Applications

- · Bulk chemical delivery
 - Acids, bases, solvents, photochemicals
- · Wet etch and clean
 - Dilute acids
 - DI water (<80°C)
- · Ultrapure electronics-grade gases

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Proflow™ II-E

Specifications

Materials of Construction

Membrane : PTFE

Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

4.6ft² (0.43 m²) 5" (130mm) cartridges 9.3ft² (0.86 m²) 10" (250mm) cartridges

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

40psid (2.8bar) @ 180°F (82°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

Cleanliness (particle shedding)

Wet-packed: <1 particles/ml >0.2μm

after 6gal at 1gpm

Data as from open bag and installed, no additional installation flushing.

TOC/Resistivity Rinse-up (wet-packed)

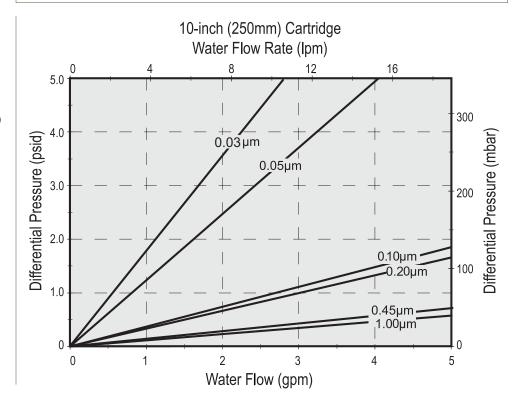
TOC rinse-up to background plus 5ppb of feed after 70gal @ 1gpm. Resistivity rinse-up to background minus 0.2megohm-cm of feed after 30gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

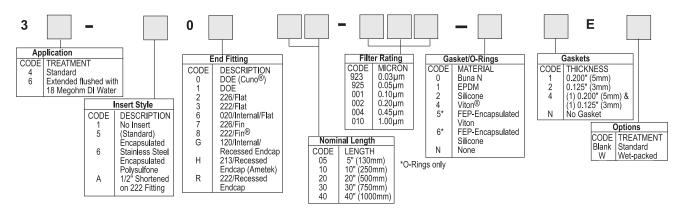
 $\begin{array}{lll} 0.03 \mu m & 0.6 gpm/psid \ (3.31 lpm/100 mbar) & 0.20 \mu m & 3.2 gpm/psid \ (17.5 lpm/100 mbar) \\ 0.05 \mu m & 0.8 gpm/psid \ (4.39 lpm/100 mbar) & 0.45 \mu m & 7.6 gpm/psid \ (41.72 lpm/100 mbar) \\ 0.10 \mu m & 1.7 gpm/psid \ (9.33 lpm/100 mbar) & 1.00 \mu m & 9.1 gpm/psid \ (49.97 lpm/100 mbar) \\ \end{array}$

*Per 10-inch (250mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Proflow™ II-E-Select

High-performance cartridge for ultrapure microelectronics fluids and gases

The Proflow™II-E-SELECT filter cartridge provides exceptional flow rates and on-stream life. It uses a PTFE membrane along with high-purity polypropylene supports that provide an economical alternative to all fluoropolymer cartridges. With its unique SELECT pleating technology, the liquid flow rates are increased by up to 50% verses our standard Proflow®II-E. This filter is ideally suited for ultrapure microelectronics fluids and gases. It is available dry or wet-packed for quick installation and lower extractables.



Benefits

- · Excellent liquid and gas flow rates
- Wet-pack option for quick installation
- PTFE/ PP construction for chemical resistance
- 100% integrity tested in cleanroom environment

Applications

- · Bulk chemical delivery
 - Acids, bases, solvents, photochemicals
- · Wet etch and clean
 - Dilute acids
 - DI water (<80°C)
- · Ultrapure electronics-grade gases

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Proflow™ II-E-Select

Specifications

Materials of Construction

Membrane : PTFE
Support layers : Polypropylene
Structure : Polypropylene

All components are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area

12.4ft2 (1.15m2) per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 68°F (20°C)

40psid (2.8bar) @ 180°F (82°C)

Reverse: 40psid (2.8bar) @ 68°F (20°C)

Cleanliness (particle shedding)

Wet-packed: <1 particles/ml >0.2μm

after 6gal at 1gpm

Data as from open bag and installed, no additional installation flushing.

TOC/Resistivity Rinse-up (wet-packed)

TOC rinse-up to background plus 5ppb of feed after 70gal @ 1gpm.
Resistivity rinse-up to background minus 0.2megohm-cm of feed after 30gal

@ 1gpm.

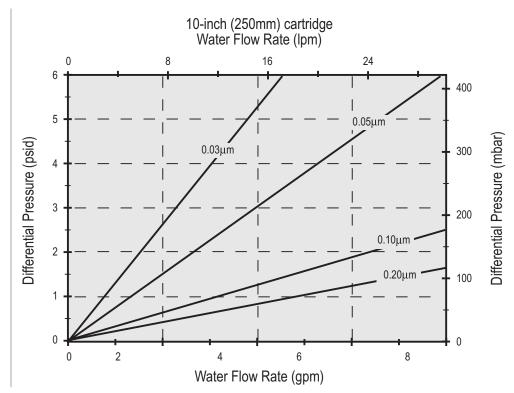
Performance Attributes

Water Flow rates, Typical *

0.03µm 0.8gpm/psid

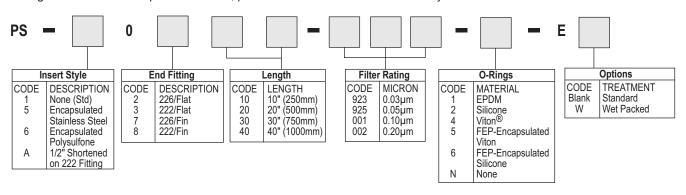
0.05μm 1.3gpm/psid (7.14lpm/100mbar) 0.10μm 2.6gpm/psid (14.27lpm/100mbar) 0.20μm 3.5gpm/psid (19.22lpm/100mbar)*

^{*} Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Proflow™ II-E Mini-Cartridges

Small-volume cartridge for ultrapure microelectronics fluids and gases

The Proflow™ II-E mini cartridge uses a PTFE membrane along with high-purity polypropylene supports that provide an economical alternative to all-fluoropolymer cartridges. It provides a high degree of retention and cleanliness along with good flow and lifetime. This filter is ideally suited for ultrapure microelectronics fluids and gases. The hydrophobic PTFE membrane serves as a highly efficient barrier to insure low moisture content of gases. Its design uses an internal 116 O-ring that is available in several materials.



Benefits

- · Good liquid and gas flow rates
- PTFE/ PP construction for chemical resistance
- · Secure internal O-ring seal
- 100% integrity tested in cleanroom environment

Applications

- · Wet etch and clean
 - Dilute acids
 - DI water (<80°C)
- · Ultrapure electronics-grade gases
- · Drying systems

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Proflow™ II-E Mini-Cartridges

Specifications

Materials of Construction

Membrane **PTFE** Support layers

Polypropylene Structure Polypropylene

All components are thermally bonded to ensure

integrity and minimize extractables.

Effective Filtration Area

3.1ft2 (0.29m2) per D-size (125mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 75°F (24°C)

35psid (2.4bar) @ 140°F (60°C) 20psid (1.4bar) @ 167°F (75°C)

Reverse: 30psid (2.1bar) @ 75°F (24°C)

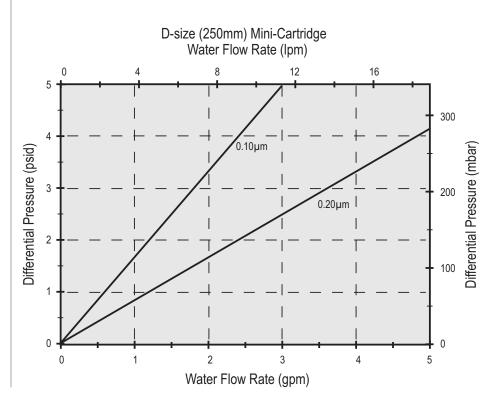
Resistivity Rinse-up

The rinse-up volume required for Proflow-E® mini-cartridges to reach 18megohm-cm resistivity is approximately 12gal (45.4 liters).

Performance Attributes

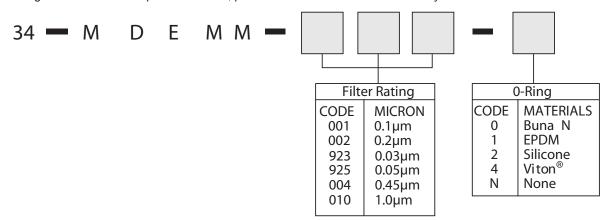
Water Flow rates, Typical

0.03µm 0.20gpm/psid 0.05µm 0.40gpm/psid 0.45µm 2.6gpm/psid



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Proflow™ II-E Mini-Capsules

Small-volume capsule for ultrapure microelectronics fluids and gases

The Proflow™ II-E mini-capsule uses a PTFE membrane along with high-purity polypropylene supports that provide an economical alternative to all-fluoropolymer cartridges. It provides a high degree of retention and cleanliness along with good flow and lifetime. This filter is ideally suited for ultrapure microelectronics fluids and gases. The hydrophobic PTFE membrane serves as a highly efficient barrier to insure low moisture content of gases.

Fast and easy change-outs are assured with the encapsulated design. Three sizes are available to match the application and minimize hold-up volume.



Benefits

- · Good liquid and gas flow rates
- PTFE/ PP construction for chemical resistance
- · Fast and easy change-out
- · Three capsule sizes
- · 100% integrity tested

Applications

- · Wet etch and clean
 - Dilute acids
 - DI water (<80°C)
- Ultrapure electronics-grade gases
- · Small-volume lab systems

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Proflow™ II-E Mini-Capsules

Specifications

Materials of Construction

Membrane : PTFE Support layers : Polypropylene

Structure : Polypropylene
Housing : Polypropylene
Polypropylene

All components are thermally bonded to ensure integrity and minimize extractables.

Effective Filtration Area

H = Half-size 1.1ft² (0.10m²) per 4.82"

(122mm) capsule

S = Standard-

size 2.2ft² (0.21m²) per 6.38"

(162mm) capsule

D = Double-size $3.1ft^2 (0.29m^2) per 7.92$ "

(201mm) capsule

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 75°F (24°C)

35psid (2.4bar) @ 140°F (60°C) 20psid (1.4bar) @ 167°F (75°C)

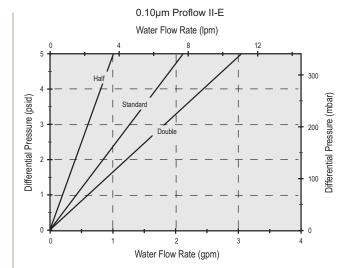
Reverse: 30psid (2.1bar) @ 75°F (24°C)

Resistivity Rinse-up

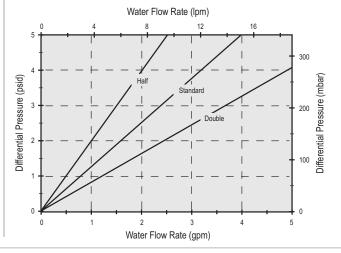
The rinse-up volume required for double-size Proflow-E™ capsules to reach 18megohm-cm resistivity is approximately 12gal (45.4 liters).

Performance Attributes

Water Flow Rates, Typical

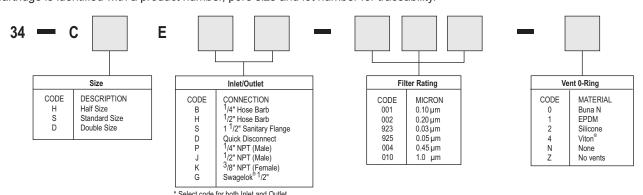






Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Clariflow®-WE

Economical hydrophilic PES membrane cartridges for aqueous applications

Clariflow®-WE cartridges provide an economical way to filter fluids used in microelectronics such as DI water and aqueous-based chemicals. Constructed of the same high-quality materials as Clariflow®-E or E-SELECT, these cartridges are suited to less demanding applications with respect to flow and lifetime.

The combination of hydrophilic PES membrane and a high-purity, all-polypropylene support structure results in a very low level of ionic and organic extractables, broad chemical compatibility, and resistance to particle shedding.

Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested in an ISO-certified facility.



Benefits

- Economical filtration
- High-retention hydrophilic membrane
- Broad chemical compatibility for multiple applications
- · 100% integrity tested

Applications

- BOE
- · Dilute HF
- POU DI rinse
- · Bulk DI water systems
- · Copper plating
- Ni plating
- · Hard disk wash processes
- · Other dilute acids and bases

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Clariflow®-WE

Specifications

Materials of Construction

Membrane : Polyethersulfone Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

5.4ft2(0.50m2) per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

40psid (2.8bar) @ 180°F (82°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

Bulk Packaging

Bulk packaged in case quantities to reduce material disposal

10" 28 per carton20" 12 per carton30" 12 per carton40" 9 per carton

Performance Attributes

Water Flow rates, Typical *

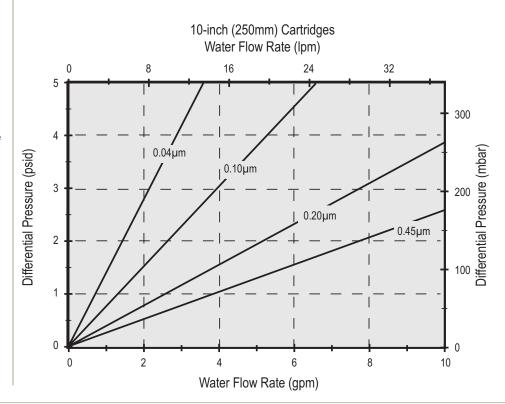
 0.04μm
 0.7gpm/psid (3.84lpm/100mbar)

 0.10μm
 1.3gpm/psid (7.14lpm/100mbar)

 0.20μm
 2.6gpm/psid (14.27lpm/100mbar)

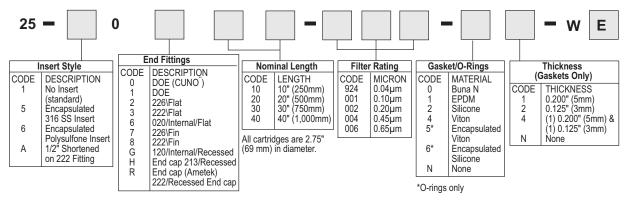
 0.45μm
 3.8gpm/psid (20.86lpm/100mbar)

*Per 10" (250mm) cartridge equivalent



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Clariflow®-E

Hydrophilic PES membrane cartridges for aqueous applications

Clariflow® -E cartridges are optimized for use in microelectronics applications such as DI water and aqueous-based chemicals. The unique mirrored-anisotropic PES (Polyethersulfone) membrane has exceptionally high flow rates and on-stream lifetime while providing consistent removal of both organic and inorganic particulates.

The combination of hydrophilic PES membrane and a high-purity, all-polypropylene support structure results in a very low level of ionic and organic extractables, broad chemical compatibility, and resistance to particle shedding.

Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested in an ISO-certified facility.



Benefits

- · High-retention hydrophilic membrane
- · High flow rate
- Broad chemical compatibility for multiple applications
- · Long on-stream life
- 100% integrity tested

Applications

- BOE
- · Dilute HF
- POU DI rinse
- · Bulk DI water systems
- · Copper plating
- Ni plating
- · Hard disk wash processes
- · Other dilute acids and bases

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Clariflow®-E

Specifications

Materials of Construction

Membrane : Polyethersulfone Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

6.8ft²(0.63m²) per 10" (250mm) cartridges

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

40psid (2.8bar) @ 180°F (82°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

Cleanliness (particle shedding)

Dry-packed: <1 particles/ml >0.2µm

after 6gal at 1gpm

Data as from open bag and installed, no additional installation flushing.

Resistivity Rinse-up

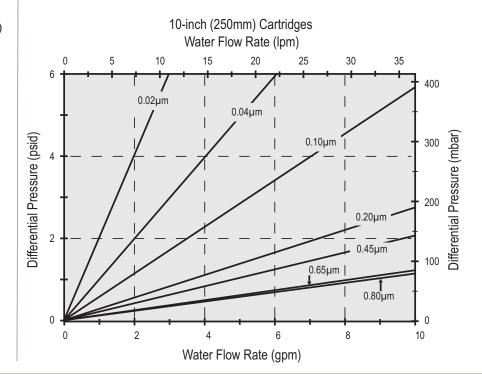
Resistivity rinse-up to background minus 0.2megohm-cm of feed after 20gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

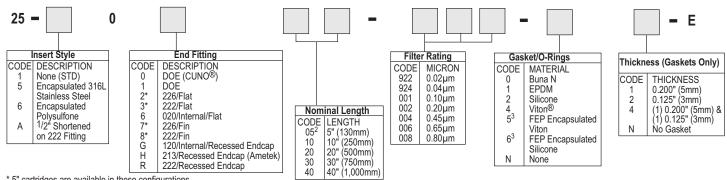
0.02μm
 0.5gpm/psid (2.75lpm/100mbar)
 0.04μm
 1.0gpm/psid (5.49lpm/100mbar)
 0.10μm
 1.8gpm/psid (9.88lpm/100mbar)
 0.20μm
 3.7gpm/psid (20.31lpm/100mbar)
 0.45μm
 4.8gpm/psid (26.35lpm/100mbar)
 0.65μm
 8.9gpm/psid (48.86lpm/100mbar)
 0.80μm
 9.5gpm/psid (52.16lpm/100mbar)

^{*} Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



* 5" cartridges are available in these configurations

² 5" cartridges are available in 0.04 through 0.8 μm ratings.

³ O-rings only.

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Clariflow®-E-Select

High-performance hydrophilic PES membrane cartridges for aqueous applications

Clariflow®-E-SELECT cartridges are optimized for use in microelectronics applications such as DI water and aqueous-based chemicals. The unique mirrored-anisotropic PES (Polyethersulfone) membrane has exceptionally high flow rates and on-stream lifetime while providing consistent removal of both organic and inorganic particulates.

The innovative SELECT pleating provides increased performance over competitive cartridges. Membrane area is increased by over 50% while flows are 40% higher within the same footprint. The result is one of the longest lasting cartridges on the market.

The combination of hydrophilic PES membrane and a high-purity, all-polypropylene support structure results in a very low level of ionic and organic extractables, broad chemical compatibility, and resistance to particle shedding.

Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested in an ISO-certified facility.

Benefits

- · High-retention hydrophilic membrane
- Unique SELECT pleating technology
- High flow rates for increased bath turnover
- Broad chemical compatibility for multiple applications
- Wide range of configurations and ratings
- Reduced overall cost of filtration
- · 100% integrity tested



Applications

- BOE
- · Dilute HF
- POU DI rinse
- · Bulk DI water systems
- · Copper plating
- Ni plating
- · Hard disk wash processes
- · Other dilute acids and bases

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Clariflow®-E-Select

Specifications

Materials of Construction

Membrane : Polyethersulfone Support Layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

8.8ft² (0.82m²) 0.02µm pore size per 10"

(250mm) cartridge

10.3ft² (0.96m²) other pore sizes per 10"

(250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 70psid (5.5bar) @ 20°C (68°F)

40psid (2.8bar) @ 82°C (180°F)

Reverse: 40psid (2.8bar) @ 20°C (68°F)

Cleanliness (particle shedding)

Dry-packed: <1 particles/ml >0.2μm

after 6gal at 1gpm

Data as from open bag and installed, no additional installation flushing.

Resistivity Rinse-up

Resistivity rinse-up to background minus 0.2megohm-cm of feed after 20gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

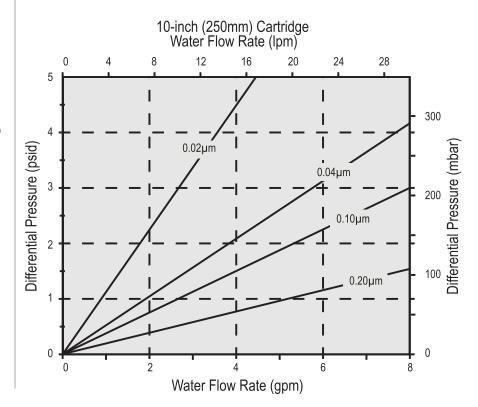
 0.02μm
 0.9gpm/psid (4.94lpm/100mbar)

 0.04μm
 1.9gpm/psid (10.43lpm/100mbar)

 0.10μm
 2.6gpm/psid (14.27lpm/100mbar)

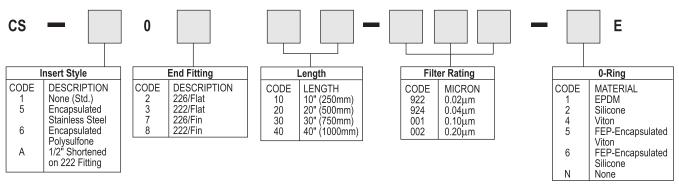
 0.20μm
 5.2gpm/psid (28.55lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Clariflow®-E Mini-Cartridges

Small-volume Hydrophilic PES membrane cartridges for aqueous applications

Clariflow®-E mini-cartridges are optimized for use in small-volume microelectronics applications such as DI water and aqueous-based chemicals. The unique mirrored-anisotropic PES (Polyethersulfone) membrane has exceptionally high flow rates and on-stream lifetime while providing consistent removal of both organic and inorganic particulates

The combination of hydrophilic PES membrane and a high-purity, all-polypropylene support structure results in a very low level of ionic and organic extractables, broad chemical compatibility, and resistance to particle shedding.

Its design uses an internal 116 O-ring available in several materials.



Benefits

- · High-retention hydrophilic membrane
- · High flow rate
- Broad chemical compatibility for multiple applications
- · Secure internal O-ring seal
- 100% integrity tested

Applications

- · Aqueous electronics chemicals
- · Small-volume lab systems
- DI water

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Clariflow®-E Mini-Cartridges

Specifications

Materials of Construction

Membrane : Polyethersulfone Support Layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

2.5ft² (0.23m²) per D-size (125mm) cartridge

Maximum Differential Pressure/ Temperature

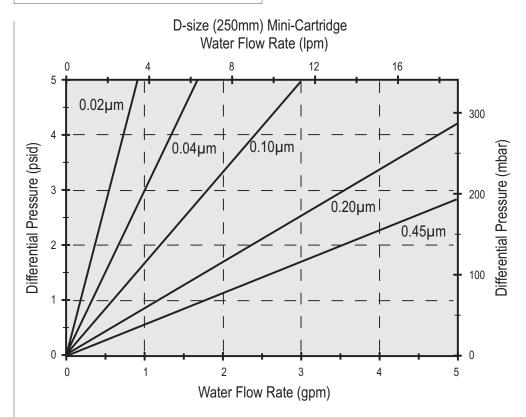
Forward: 70psid (4.8bar) @ 75°F (24°C)

35psid (2.4bar) @ 140°F (60°C) 20psid (1.4bar) @ 167°F (75°C)

Reverse: 30psid (2.1bar) @ 75°F (24°C)

Performance Attributes

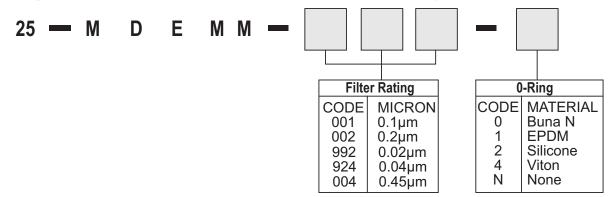
Water Flow Rates, Typical



*Values for fluids with viscosity of 1cP.

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Clariflow®-E Mini-Capsules

Encapsulated PES membrane filters for microelectronics applications

Clariflow®-E capsules filter high-quality water and solvents in semiconductor and microelectronics applications. The mirrored anisotropic polyethersulfone (PES) membrane provides superior fluid flow rates, extended on-stream life, and highly efficient removal of organic and inorganic particulates that can impact process quality.

Clariflow-E capsules are available in a variety of sizes and endfitting combinations enabling users select the best configuration for their system requirements.

The encapsulated design maximizes efficiency by providing faster, easier change-out without laborious cleaning procedures. Eliminating the need to open reusable housings for cartridge replacement minimizes the chance of introducing contamination into the process, and promotes safety by reducing the risk of exposure to potentially hazardous fluids.

Benefits

- Reduce process down time, chance of contamination and risk of exposure to hazardous materials
- · Low extractables shorten start-up time
- High flow rate reduces processing time
- Improved design prevents vent caps from disconnecting under pressure



Applications

- Deionized water at point-of-use
- · Aqueous chemical fluids

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Clariflow®-E Mini-Capsules

Specifications

Materials of Construction

Polyethersulfone Membrane Polypropylene Support layers Polypropylene Structure Polypropylene Housing

All components are thermally bonded to ensure

integrity and reduce extractables.

Effective Filtration Area

0.9ft2 (0.08m2) per 4.82" H = Half-size

(122mm) capsule

S = Standard-

1.8ft2 (0.16m2) per 6.38" size

(162mm) capsule

D = Double-size $2.5ft^2 (0.23m^2) per 7.92$ "

(201mm) capsule

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 75°F (24°C)

35psid (2.4bar) @ 140°F (60°C) 20psid (1.4bar) @ 167°F (75°C)

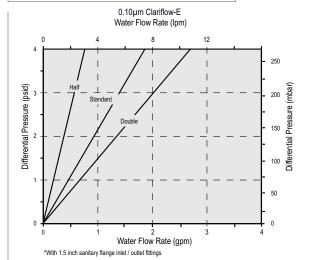
Reverse: 30psid (2.1bar) @ 75°F (24°C)

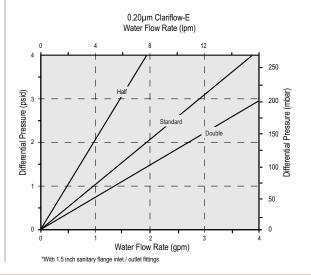
Resistivity Rinse-up

The rinse-up volume required for double-size Clariflow® -E capsules to reach 18megohm-cm resistivity is approximately 12gal (45.4 liters).

Performance Attributes

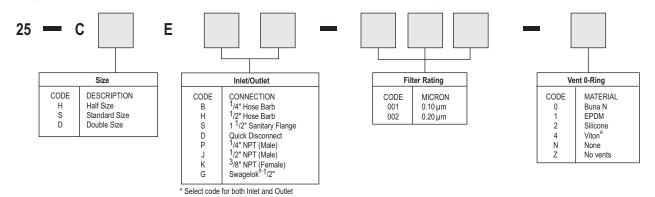
Water Flow Rates, Typical





Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Clariflow®-E

Hydrophilic PES membrane cartridges for aqueous applications

Clariflow® -E cartridges are optimized for use in microelectronics applications such as DI water and aqueous-based chemicals. The unique mirrored-anisotropic PES (Polyethersulfone) membrane has exceptionally high flow rates and on-stream lifetime while providing consistent removal of both organic and inorganic particulates.

The combination of hydrophilic PES membrane and a high-purity, all-polypropylene support structure results in a very low level of ionic and organic extractables, broad chemical compatibility, and resistance to particle shedding.

Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested in an ISO-certified facility.



Benefits

- · High-retention hydrophilic membrane
- · High flow rate
- Broad chemical compatibility for multiple applications
- · Long on-stream life
- 100% integrity tested

Applications

- BOE
- · Dilute HF
- POU DI rinse
- · Bulk DI water systems
- · Copper plating
- Ni plating
- · Hard disk wash processes
- · Other dilute acids and bases

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Clariflow®-E

Specifications

Materials of Construction

Membrane Polyethersulfone Polypropylene Support layers Structure Polypropylene

Effective Filtration Area

6.8ft2(0.63m2) per 10" (250mm) cartridges

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

40psid (2.8bar) @ 180°F (82°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

Cleanliness (particle shedding)

Dry-packed: <1 particles/ml >0.2µm

after 6gal at 1gpm

Data as from open bag and installed, no additional installation flushing.

Resistivity Rinse-up

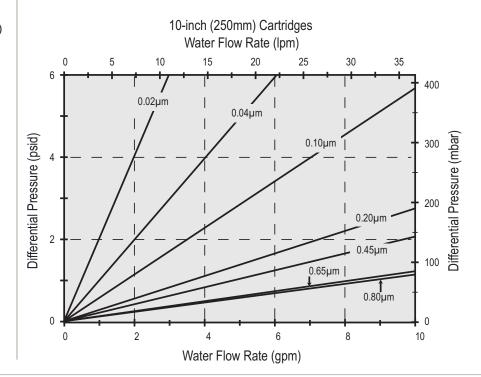
Resistivity rinse-up to background minus 0.2megohm-cm of feed after 20gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

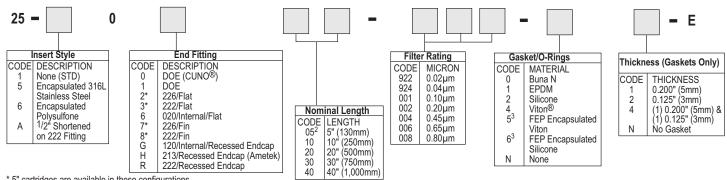
0.02µm 0.5gpm/psid (2.75lpm/100mbar) 0.04µm 1.0gpm/psid (5.49lpm/100mbar) 0.10µm 1.8gpm/psid (9.88lpm/100mbar) 0.20µm 3.7gpm/psid (20.31lpm/100mbar) 0.45µm 4.8gpm/psid (26.35lpm/100mbar) 0.65µm 8.9gpm/psid (48.86lpm/100mbar) 0.80µm 9.5gpm/psid (52.16lpm/100mbar)

^{*} Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



* 5" cartridges are available in these configurations

² 5" cartridges are available in 0.04 through 0.8 μm ratings.

³ O-rings only.

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Clariflow®-E-Select

High-performance hydrophilic PES membrane cartridges for aqueous applications

Clariflow®-E-SELECT cartridges are optimized for use in microelectronics applications such as DI water and aqueous-based chemicals. The unique mirrored-anisotropic PES (Polyethersulfone) membrane has exceptionally high flow rates and on-stream lifetime while providing consistent removal of both organic and inorganic particulates.

The innovative SELECT pleating provides increased performance over competitive cartridges. Membrane area is increased by over 50% while flows are 40% higher within the same footprint. The result is one of the longest lasting cartridges on the market.

The combination of hydrophilic PES membrane and a high-purity, all-polypropylene support structure results in a very low level of ionic and organic extractables, broad chemical compatibility, and resistance to particle shedding.

Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested in an ISO-certified facility.

Benefits

- · High-retention hydrophilic membrane
- Unique SELECT pleating technology
- High flow rates for increased bath turnover
- Broad chemical compatibility for multiple applications
- Wide range of configurations and ratings
- Reduced overall cost of filtration
- · 100% integrity tested



Applications

- BOE
- Dilute HF
- POU DI rinse
- · Bulk DI water systems
- · Copper plating
- Ni plating
- · Hard disk wash processes
- · Other dilute acids and bases

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Clariflow®-E-Select

Specifications

Materials of Construction

Membrane : Polyethersulfone Support Layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

8.8ft² (0.82m²) 0.02µm pore size per 10"

(250mm) cartridge

 $10.3 ft^2 (0.96 m^2)$ other pore sizes per 10"

(250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 70psid (5.5bar) @ 20°C (68°F)

40psid (2.8bar) @ 82°C (180°F)

Reverse: 40psid (2.8bar) @ 20°C (68°F)

Cleanliness (particle shedding)

Dry-packed: <1 particles/ml >0.2μm

after 6gal at 1gpm

Data as from open bag and installed, no additional installation flushing.

Resistivity Rinse-up

Resistivity rinse-up to background minus 0.2megohm-cm of feed after 20gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

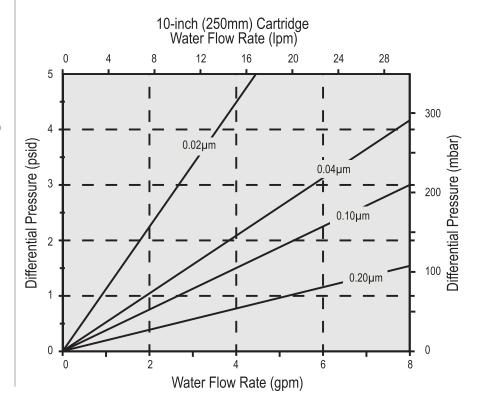
 0.02μm
 0.9gpm/psid (4.94lpm/100mbar)

 0.04μm
 1.9gpm/psid (10.43lpm/100mbar)

 0.10μm
 2.6gpm/psid (14.27lpm/100mbar)

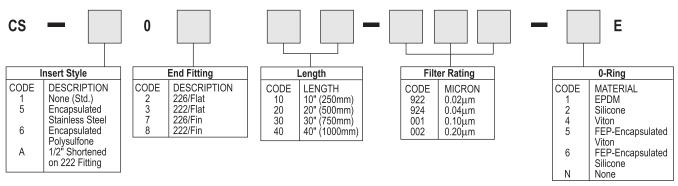
 0.20μm
 5.2gpm/psid (28.55lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow®

Absolute-rated polypropylene depth cartridges for electronics applications

Polyflow® cartridges are optimized for use in electronics applications. They feature a random-fiber polypropylene depth matrix that provides excellent retention efficiencies and onstream life. The unique calendering process produces depth media with an absolute rating and superior dirt-holding capacity.

These cartridges are thermally bonded from 100% virgin polypropylene to ensure a high level of cleanliness and chemical compatibility.



Benefits

- · High-retention depth matrix
- · High flow rate
- Wide variety of configurations and ratings
- · Economical prefiltration

Applications

- Solder plating
- Prefiltration of electronics-grade chemicals
- · DI water

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Specifications

Materials of Construction

Depth media : Polypropylene Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

2.4ft² (0.22 m²) 5" (130mm) cartridges 4.9ft² (0.46 m²) 10" (250mm) cartridges

Filtration Efficiency

The 0.6µm offers typical retention up to 99% efficient. 1.2µm, 2.5µm, 5µm, 10µm, 20µm, and 40µm are up to 99.9% efficient at specified pore size.

Cartridge Extractables

NVR < 35mg per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

Reverse: 40psid (2.8bar) @ 75°F (24°C) 15psid (1.0bar) @ 140°F (60°C)

Maximum Operating Temperature

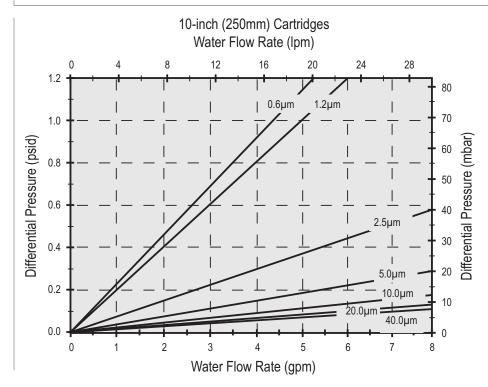
160°F (71°C)

Performance Attributes

Water Flow rates, Typical *

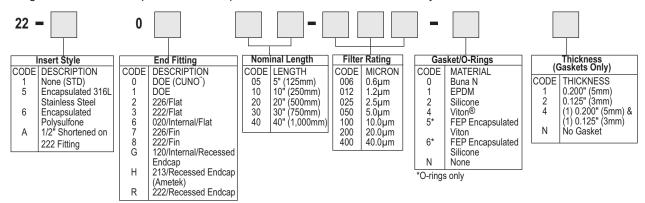
0.6μm 4.2gpm/psid (23.3lpm/100mbar)
 1.2μm 5.0gpm/psid (27.4lpm/100mbar)
 2.5μm 13.5gpm/psid (74.1lpm/100mbar)
 5.0μm 26.0gpm/psid (142.7lpm/100mbar)
 10.0μm 40.0gpm/psid (219.6lpm/100mbar)
 20.0μm 50.0gpm/psid (274.4lpm/100mbar)
 40.0μm 60.0gpm/psid (329.3lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow®-CMP

All-polypropylene nominalrated depth cartridges for CMP slurry filtration

Polyflow®-CMP depth cartridges have been developed to reduce post-CMP defectively by removing undesirable large particles and gels from a wide variety of CMP slurries. Its high dirt-loading, random-fiber depth media provides consistent particle retention in ratings from 0.2 µm to 30 µm without removing a significant amount of smaller 'working particles'. The cartridges are thermally bonded from 100% virgin polypropylene to ensure low extractables and chemical compatibility with both acidic and alkaline slurries.

Configurations are available in lengths from 5" to 40" with 10 fitting options. The specially-designed depth media maximizes flow rate and service life to reduce downtime associated with change-outs.



Benefits

- Removes undesirable large particles while retaining working slurry particles
- Chemically compatible with both acidic and alkaline slurries
- High flow rate and long service life reduce system downtime
- Superior particle retention protects downstream filters and reduces overall filtration costs

Applications

- · Colloidal silica CMP slurry
- POU, distribution loop and supply
 - Oxide
 - Copper
 - Polysilicon

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Polyflow®-CMP

Specifications

Materials of Construction

Depth media : Polypropylene Support layers : Polypropylene Structure : Polypropylene

All components are thermally bonded to ensure integrity and to reduce extractables.

Nominal Filter Ratings

 $0.2\mu m, \, 0.5\mu m, \, 1\mu m, \, 3\mu m, \, 5m, \, 10\mu m, \, and \, 30\mu m$

Effective Filtration Area

3.6ft2 (0.33 m2) per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

40psid (2.8bar) @ 75°F (24°C) 15psid (1.0bar) @ 140°F (60°C)

Maximum Operating Temperature

160°F (71°C)

Reverse:

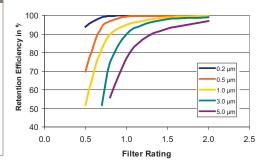
Performance Attributes

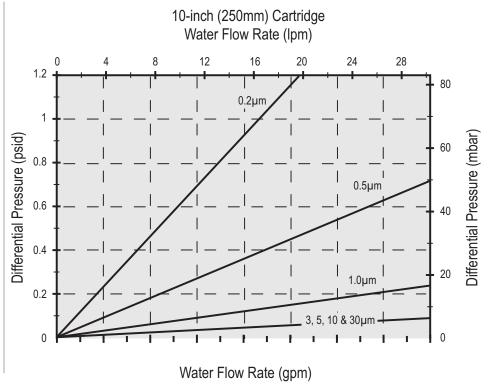
Water Flow rates, Typical *

0.2μm
0.5μm
11.0gpm/psid (60.4lpm/100mbar)
1.0μm
33.0gpm/psid (181.1lpm/100mbar)
3.0μm
70.0gpm/psid (384.2lpm/100mbar)
5.0μm
70.0gpm/psid (384.2lpm/100mbar)
10.0μm
70.0gpm/psid (384.2lpm/100mbar)
70.0gpm/psid (384.2lpm/100mbar)
70.0gpm/psid (384.2lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.

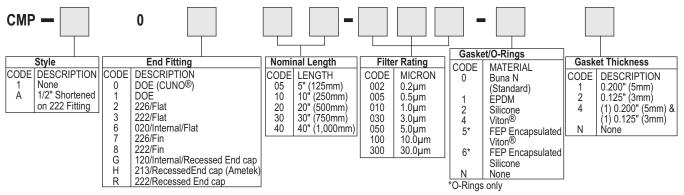
Retention Efficiency





Ordering Information

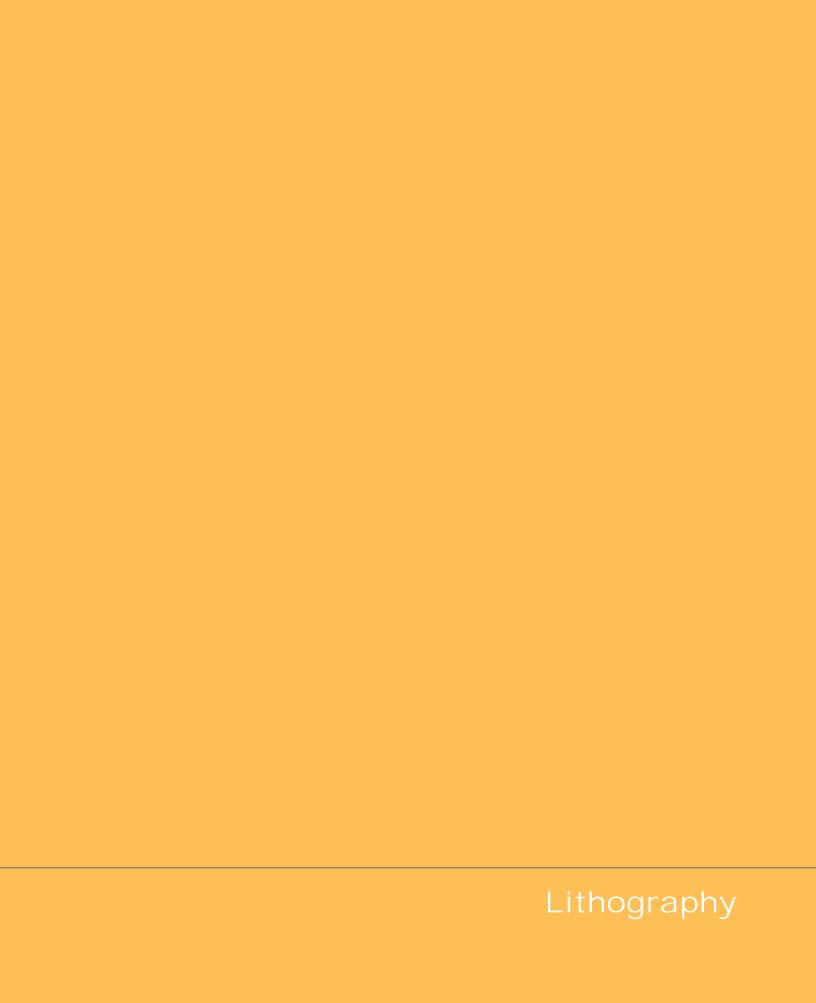
Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow[®] Membrane

Polypropylene membrane cartridges for microelectronics

Polyflow® Membrane cartridges are optimized for use in microelectronics applications such as bulk chemicals and photoresists. The all-polypropylene construction is an economical alternative to fluoropolymer-based cartridges.

Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested in an ISO-certified facility.



Benefits

- · High-retention membrane
- Wide range of configurations and ratings
- · 100% integrity tested

Applications

- · Bulk photoresist
- · Bulk electronics grade chemicals

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Polyflow® Membrane

Specifications

Materials of Construction

Membrane : Polypropylene Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

7.7ft² (0.72m²) 0.04 pore size per 10" (250mm) cartridge

6.6ft² (0.61m²) 0.07 pore size per 10" (250mm) cartridge*

7.7ft² (0.72m²) 0.1 pore size per 10" (250mm) cartridge

7.7ft² (0.72m²) 0.2 pore size per 10" (250mm) cartridge

* double layers of membrane

Metals Extractables*

<50ppb (total)

*in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)*

40psid (2.8bar) @ 180°F (82°C)

Reverse: 40psid (2.8bar) @ 75°F (24°C)

60 psid (4.1 Bar) @ 75°F for 0.04µm

Cleanliness (particle shedding)

Wet-packed <1 particles/ml >0.2µm after

10gal at 1gpm

Data from bag open and installed, no additional installation flushing.

Performance Attributes

Water Flow rates, Typical *

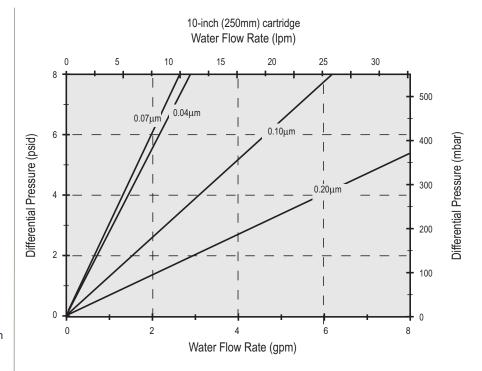
 0.04μm
 0.41gpm/psid (2.2lpm/100mbar)

 0.07μm
 0.35gpm/psid (1.9lpm/100mbar)

 0.10μm
 0.7gpm/psid (3.8lpm/100mbar)

 0.20μm
 1.8gpm/psid (10.3lpm/100mbar)

* Per 10-inch (250 mm) cartridge equivalent.

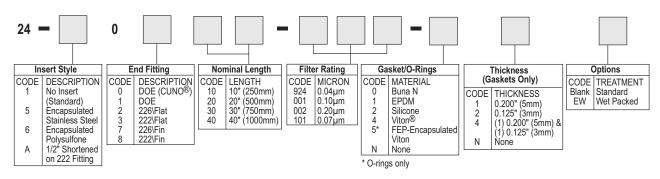


TOC/Resistivity Rinse-up (wet-packed) TOC rinse-up to background plus 5ppb of feed after 40gal @ 1gpm.

Resistivity rinse-up to background minus 0.2megohm-cm of feed after 40gal @ 1gpm.

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow® Membrane-Select

High-performance polypropylene membrane cartridges for microelectronics

Polyflow® MEMBRANE-SELECT cartridges are optimized for use in microelectronics applications such as bulk chemicals and photoresists. The all-polypropylene construction is an economical alternative to fluoropolymer-based cartridges.

The innovative SELECT pleating provides increased performance over competitive cartridges. Membrane area is increased by about 30% while flows are more than 50% higher within the same footprint. The result is one of the longest-lasting cartridges on the market.

Every cartridge is fabricated in a clean room environment, pre-flushed with 18 megohm-cm ultrapure DI water, and 100% integrity tested in an ISO-certified facility.



- · High-retention membrane
- Unique SELECT pleating technology
- · High flow rates
- Wide range of configurations and ratings
- 100% integrity tested



Applications

- Bulk photoresist
- · Bulk electronics grade chemicals

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Polyflow® Membrane-Select

Specifications

Materials of Construction

Membrane : Polypropylene Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

11.5ft² (1.07m²) 0.04 pore size per 10" (250mm) cartridge

8.4ft² (0.78m²) 0.07 pore size per 10" (250mm) cartridge*

10.1ft² (0.94m²) 0.10 pore size per 10" (250mm) cartridge

9.8ft² (0.88m²) 0.20 pore size per 10" (250mm) cartridge

* double layers of membrane

Metals Extractables*

<50ppb (total)

*in a 10% HNO₃ extraction

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 68°F (20°C)*

40psid (2.8bar) @ 158°F (70°C)

Reverse: 30psid (2.1bar) @ 68°F (20°C)

60 psid (4.1 Bar) @ 68°F for 0.04µm

Cleanliness (particle shedding)

Wet-packed <1 particles/ml >0.2µm after

10gal at 1gpm

Data as from bag open and installed, no additional installation flushing.

Performance Attributes

Water Flow rates, Typical *

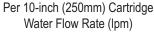
 0.04μm
 0.65gpm/psid (3.6lpm/100mbar)

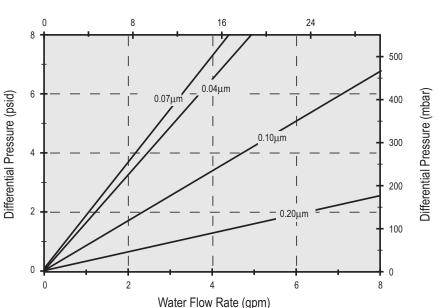
 0.07μm
 0.55gpm/psid (3.0lpm/100mbar)

 0.10μm
 1.2gpm/psid (6.5lpm/100mbar)

 0.20μm
 3.0gpm/psid (16.5lpm/100mbar)

* Per 10-inch (250 mm) cartridge equivalent.



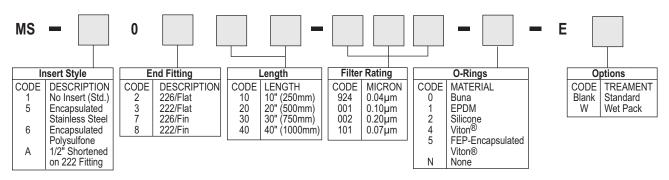


TOC/Resistivity Rinse-up (wet-packed) TOC rinse-up to background plus 5ppb of feed after 40gal @ 1gpm.

Resistivity rinse-up to background minus 0.2megohm-cm of feed after 40gal @ 1gpm.

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Chemflow®-PE

Chemically-resistant cartridge for bulk and lower temperature applications

The Chemflow®-PE filter cartridge uses a PTFE membrane along with HDPE supports that provide an economical alternative to all-fluoropolymer cartridges. It provides a high degree of retention and cleanliness along with good flow and lifetime. This filter is ideally suited for bulk chemical delivery and lower temperature wet processes (<60°C). It is available dry or wetpacked for quick installation.



Benefits

- · Good flow rates
- · Long lifetime
- Wet-pack option for quick installation
- PTFE/ HDPE construction for chemical resistance
- 100% integrity tested in cleanroom environment

Applications

- · Bulk chemical delivery
 - Acids, bases, solvents, photochemicals
 - Wet etch and clean (< 60°C)
 - Phosphoric acid
 - Hydrofluoric acid
 - Nitric acid
 - SC1,SC2
 - Solvents

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Chemflow®-PE

Specifications

Materials of Construction

Membrane : PTFE Support Layers : HDPE Structure : HDPE

Effective Filtration Area

8.3ft² (0.78m²) per 10" (250mm) cartridge

Metals Extractables*

Standard: <55ppb (total)
*in a 10% HNO3 extraction

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C) Reverse: 50psid (3.4bar) @ 75°F (24°C)

Maximum Operating Temperature

140°F (60°C)

Cleanliness (particle shedding)

Wet-packed: <1 particles/ml >0.2µm after

5gal at 1gpm

Data is from open bag and installed, no additional

installation flushing.

TOC/Resistivity Rinse-up (wet-packed)

TOC rinse-up to background plus 5ppb of feed after 70gal @ 1gpm. Resistivity rinse-up to background minus 0.2 megohm-cm of feed after 60gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

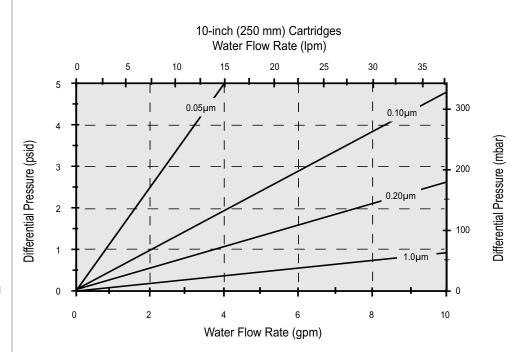
 0.05μm
 0.8gpm/psid (4.39lpm/100mbar)

 0.10μm
 2.1gpm/psid (11.53lpm/100mbar)

 0.20μm
 3.8gpm/psid (20.86lpm/100mbar)

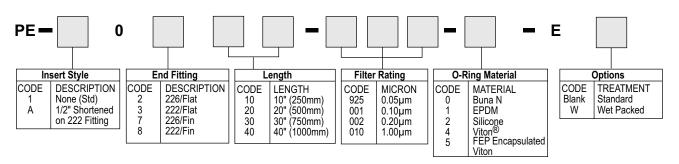
 1.0μm
 10gpm/psid (55.0lpm/100bar)

* Per 10-inch (250mm) cartridge equivalent.



Ordering Information

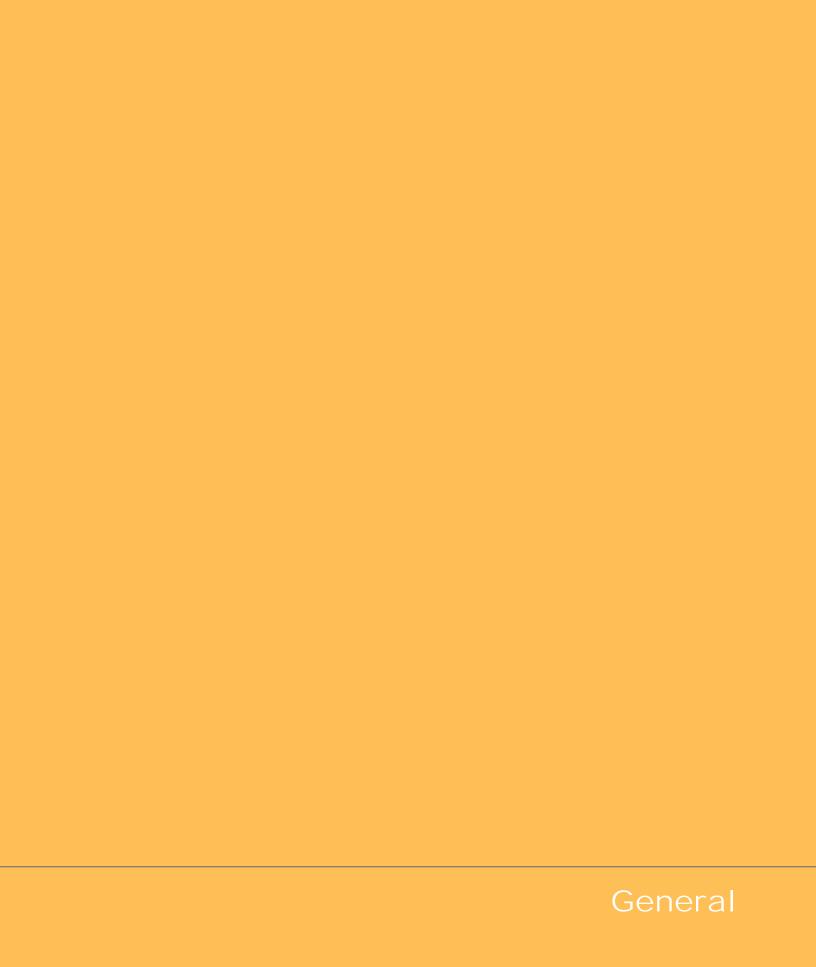
Each cartridge is identified with a product number, pore size and lot number for traceability.



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Proflow™ II-G

Hydrophobic PTFE membrane for general purpose gas and solvent purification

Proflow™ II-G cartridges provide an economic alternative for general applications where reliable gas and liquid flow rates are required. With 5.6 square feet of expanded PTFE membrane, Proflow II-G is a highly efficient hydrophobic barrier, for the production of dry gas, and will effectively purify aggressive liquids and organic solvents.

Proflow™ II-G cartridges are manufactured under cleanroom conditions and integrity tested before shipment to assure consistent performance and quality.



Benefits

- Reliable air and liquid flow rates for effective performance
- Broad chemical compatibility enables use in many applications
- Broad range of micron ratings for user convenience
- Superior hydrophobicity for long life in vent/air applications
- · Integrity tested to ensure quality

Applications

- Photoresists
- · Compressed gas
- · Non-sterile venting
- · Electronic grade solvents
- Hot deionized water (less than 80°C)

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Proflow™ II-G

Specifications

Materials of Construction

Membrane : PTFE

Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

5.6ft² (0.52 m²) per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

40psid (2.8bar) @ 180°F (82°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

Cleanliness (particle shedding)

Wet-packed: <1 particles/ml >0.2μm

after 6gal at 1gpm

Data as from open bag and installed, no additional installation flushing.

TOC/Resistivity Rinse-up (wet-packed)

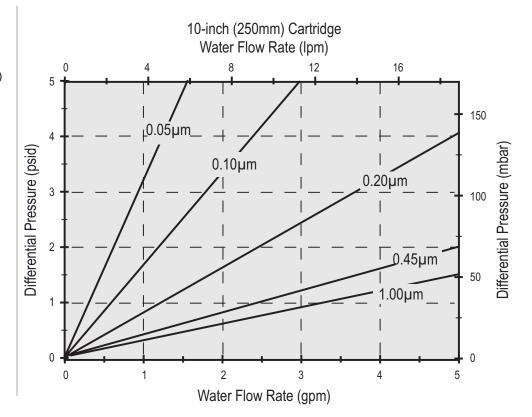
TOC rinse-up to background plus 5ppb of feed after 70gal @ 1gpm. Resistivity rinse-up to background minus 0.2megohm-cm of feed after 30gal @ 1gpm.

Performance Attributes

Water Flow rates, Typical *

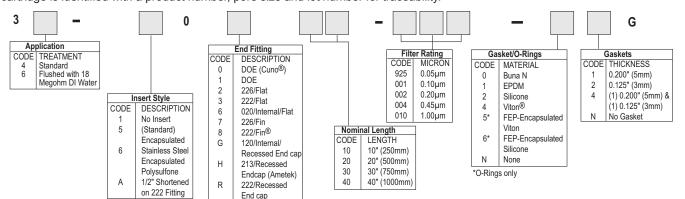
0.05μm 0.6gpm/psid (3.29lpm/100mbar)
 0.10μm 1.2gpm/psid (6.59lpm/100mbar)
 0.20μm 2.5gpm/psid (13.73lpm/100mbar)
 0.45μm 5.1gpm/psid (28.00lpm/100mbar)
 1.00μm 6.2gpm/psid (34.04lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Clariflow®-G

Hydrophilic Polyethersulfone (PES) membrane for aqueous liquid filtration applications

Clariflow®-G cartridges are designed for general-purpose use in the filtration of high-purity liquids and aqueous chemicals.

The mirrored-anisotropic Polyethersulfone (PES) membrane is inherently hydrophilic and has a pore morphology that delivers exceptionally high flow rates.

Because there are no added surfactants or wetting agents, and the support layers and structure are all-polypropylene, the filter exhibits low extractables, broad chemical compatibility and good resistance to hydrolysis.



Benefits

- High flow rate reduces processing time
- Broad chemical compatibility allows use in most applications
- Low differential pressure reduces system wear and tear
- · Chemical filtration

Applications

- · Chemical filtration
- · Liquid clarification
- Recirculating fluids
- · General use water filtration
- · Deionized water systems

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Clariflow®-G

Specifications

Materials of Construction

Membrane : Polyethersulfone Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

6.8ft² (0.63m²) per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C)

40psid (2.8bar) @ 180°F (82°C)

Reverse: 50psid (3.4bar) @ 75°F (24°C)

Maximum Operating Temperature

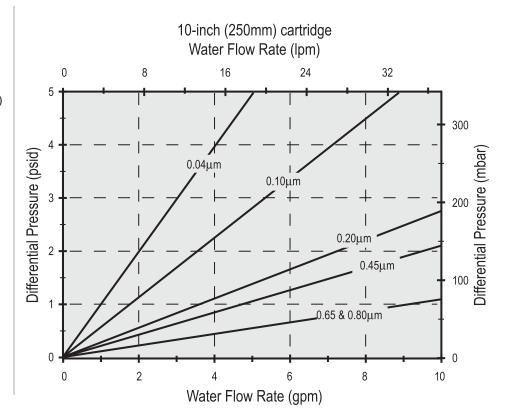
160°F (71°C)

Performance Attributes

Water Flow rates, Typical *

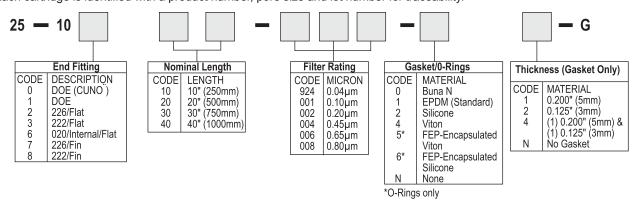
0.04μm
 1.0gpm/psid (5.29lpm/100mbar)
 0.10μm
 1.8gpm/psid (9.88lpm/100mbar)
 0.20μm
 3.7gpm/psid (20.31lpm/100mbar)
 0.80μm
 9.2gpm/psid (50.51lpm/100mbar)
 0.80μm
 9.5gpm/psid (52.16lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow[®]

Absolute-rated polypropylene depth cartridges for electronics applications

Polyflow® cartridges are optimized for use in electronics applications. They feature a random-fiber polypropylene depth matrix that provides excellent retention efficiencies and onstream life. The unique calendering process produces depth media with an absolute rating and superior dirt-holding capacity.

These cartridges are thermally bonded from 100% virgin polypropylene to ensure a high level of cleanliness and chemical compatibility.



Benefits

- · High-retention depth matrix
- · High flow rate
- Wide variety of configurations and ratings
- · Economical prefiltration

Applications

- Solder plating
- Prefiltration of electronics-grade chemicals
- · DI water

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Specifications

Materials of Construction

Depth media : Polypropylene Support layers : Polypropylene Structure : Polypropylene

Effective Filtration Area

2.4ft² (0.22 m²) 5" (130mm) cartridges 4.9ft² (0.46 m²) 10" (250mm) cartridges

Filtration Efficiency

The 0.6µm offers typical retention up to 99% efficient. 1.2µm, 2.5µm, 5µm, 10µm, 20µm, and 40µm are up to 99.9% efficient at specified pore size.

Cartridge Extractables

NVR < 35mg per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C) Reverse: 40psid (2.8bar) @ 75°F (24°C)

15psid (1.0bar) @ 140°F (60°C)

Maximum Operating Temperature

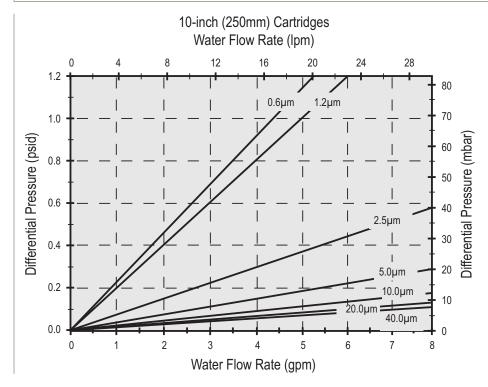
160°F (71°C)

Performance Attributes

Water Flow rates, Typical *

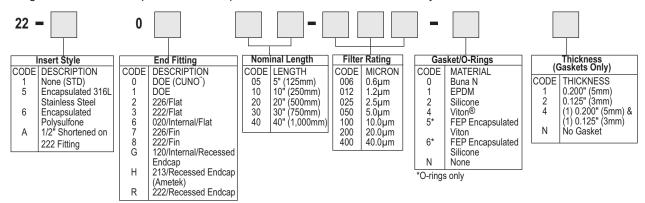
0.6μm 4.2gpm/psid (23.3lpm/100mbar)
 1.2μm 5.0gpm/psid (27.4lpm/100mbar)
 2.5μm 13.5gpm/psid (74.1lpm/100mbar)
 5.0μm 26.0gpm/psid (142.7lpm/100mbar)
 10.0μm 40.0gpm/psid (219.6lpm/100mbar)
 20.0μm 50.0gpm/psid (274.4lpm/100mbar)
 40.0μm 60.0gpm/psid (329.3lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow®-G

All-polypropylene nominalrated depth cartridges for economical prefiltration

Polyflow®-G depth media has been developed for a wide variety of general process applications from fluid clarification to general prefiltration. Its high dirt-loading, random-fiber polypropylene depth media provides consistent particle retention. Polyflow®-G is thermally bonded from 100% virgin polypropylene to ensure clean filtrates and excellent chemical and thermal compatibility in the most demanding processing conditions.

Polyflow®-G leads in overall reduction of filtration costs when compared to spunbonded, stringwound, and nominally-rated pleated prefilter cartridges. Its longer filtration life reduces downtime due to fewer change-outs.



Benefits

- High flow rate and long service life reduce processing time
- Broad chemical compatibility allows use in most applications
- Thermally bonded construction minimizes extractables for cleaner filtrates

Applications

- Solvent filtration
- Liquid clarification
- Recirculating liquids
- General water filtration
- · Reagent grade chemicals
- RO/DI prefiltration
- · Waste water

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Polyflow®-G

Specifications

Materials of Construction

Depth media : Polypropylene Support layers : Polypropylene Structure : Polypropylene

All components are thermally bonded to ensure integrity and to reduce extractables.

Nominal Filter Ratings

0.2µm, 0.5µm, 1µm, 3µm, 10µm, and 30µm

Effective Filtration Area

3.6ft² (0.33 m²) per 10" (250mm) cartridge

Cartridge Extractables

NVR < 35mg per 10" (250mm) cartridge

Biological Safety

All components meet USP specifications for Class VI-121°C Plastics criteria.

Maximum Differential Pressure/ Temperature

Forward: 80psid (5.5bar) @ 75°F (24°C) Reverse: 40psid (2.8bar) @ 75°F (24°C)

15psid (1.0bar) @ 140°F (60°C)

Maximum Operating Temperature

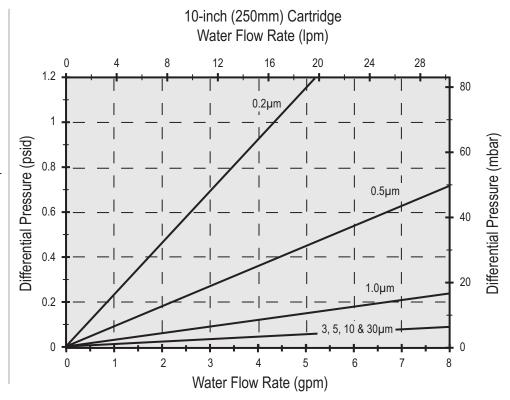
160°F (71°C)

Performance Attributes

Water Flow rates, Typical *

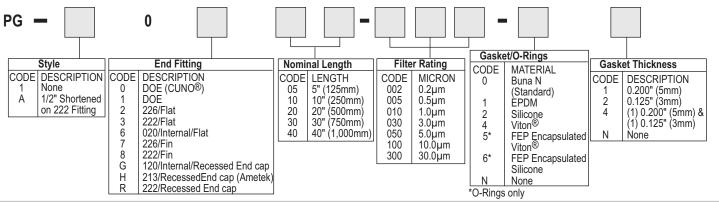
0.2μm 4.2gpm/psid (23.3lpm/100mbar)
 0.5μm 11.0gpm/psid (60.4lpm/100mbar)
 1.0μm 33.0gpm/psid (181.1lpm/100mbar)
 30.0μm 70.0gpm/psid (384.2lpm/100mbar)
 70.0gpm/psid (384.2lpm/100mbar)
 70.0gpm/psid (384.2lpm/100mbar)
 70.0gpm/psid (384.2lpm/100mbar)

*Per 10-inch (250 mm) cartridge equivalent.



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow® Mini-Cartridges

Small-volume polypropylene depth cartridges for electronics applications

Polyflow® mini-cartridges are optimized for use in small-volume applications such as DI water and aqueous-based chemicals. They feature a random-fiber polypropylene depth matrix that provides excellent retention efficiencies. The unique calendering process produces depth media with superior dirt-holding capacity that extends useful life.

Its design uses an internal 116 O-ring that is available in several materials.



Benefits

- · High-retention depth matrix
- · High flow rate
- · Economical prefiltration
- · Secure internal O-ring seal

Applications

- Prefiltration of electronics-grade chemicals
- · Small-volume lab systems
- · DI water

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Polyflow[®] Mini-Cartridges

Specifications

Materials of Construction

Depth Media : Polypropylene Support Layers : Polypropylene Structure : Polypropylene

Effective Filtration Areas

 $0.9 ft^2 \, (0.08 m^2)$ per 5" (125mm) cartridge (0.6 $\mu m)$

 $1.6ft^{2}(0.15m^{2})$ per 5" (125mm) cartridge (1.2 μ m)

 $2.0 ft^2 (0.19 m^2)$ per 5" (125mm) cartridge (2.5 $\mu m)$

 $2.1 ft^2 (0.20 m^2)$ per 5" (125mm) cartridge (5.40 μ m)

Filtration Efficiency

The $0.6\mu m$ offers typical retention efficiency of up to $97-99\%.1.2\mu m$, $2.5\mu m$, $5.0\mu m$, and $10.0\mu m$ are 99.9% efficient at the specified pore size.

Cartridge Extractables

NVR < 3mg per 10" (250mm) cartridge

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 75°F (24°C)

35psid (2.4bar) @ 140°F (60°C) 20psid (1.4bar) @ 167°F (75°C)

Reverse: 30psid (2.1bar) @ 75°F (24°C)

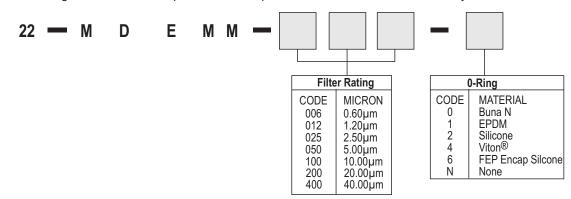
Performance Attributes

FILTER	NOMI EF			PICAL FLOW RATE*	TYPICAL AIR FLOW RATE				
RATING	ft ²	cm ²	gpm/psid	lpm/100mbar	scfm/psid	Cubic Meters ³ /hr/ 100mbar			
0.60µm	0.9	836	1.0	5.5	7.6	18.8			
1.20µm	1.6	1486	2.1	11.5	12.0	24.0			
2.50µm	2.0	1858	3.3	18.1	15.4	38.1			
5.00µm	2.1	1950	6.0	32.9	20.0	49.5			
10.00µm	2.1	1950	6.5	35.7	26.6	65.7			
20.00µm	2.1	1950	25	137 90		221.7			
40.00µm	2.1	1950	40	219.5	220	541.86			

^{*}For fluids with viscosity of 1cP.

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Polyflow[®] Mini-Capsules

Encapsulated filters with polypropylene depth matrix for small-volume prefiltration applications

Polyflow® Capsules feature a randomfiber polypropylene depth matrix that provides superior retention efficiencies. In addition, the unique calendering process produces depth media with unsurpassed dirt-holding capacity that extends filter service life. Longer life leads to increased savings by requiring fewer filter changeouts.

Polyflow® capsules are available in three sizes, enabling users to match the filters to actual batch sizes and minimize the hold-up volume. Cost savings result from the reduction of lost product, and by scaling the process properly to avoid excess filter capacity.

The encapsulated design maximizes efficiency by providing faster, easier change-out without laborious cleaning procedures. Eliminating the need to open reusable housings for cartridge replacement minimizes the chance of introducing contamination into the process, and promotes safety by reducing the risk of exposure to potentially hazardous fluids.

Benefits

- High flow rate reduces processing time
- Long service life minimizes change out frequency
- Broad chemical compatibility enables use in most applications
- High retention efficiency provides excellent protection for downstream filters



- Non-pyrogenic (per LAL test) for use in critical applications
- Custom ordering option allows different inlet/outlet fittings for specific needs

Applications

- · Solvent and reagent grade chemicals
- · Lab scale RO/DI pre-filtration
- · Recirculating liquids
- · General water filtration
- Vent filtration

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Polyflow[®] Mini-Capsules

Specifications

Materials of Construction

Depth media : Polypropylene
Support layers : Polypropylene
Structure : Polypropylene
Housing : Polypropylene

All components meet USP-XXIV Class VI-121°C criteria, and are thermally bonded to ensure integrity and reduce extractables.

Effective Filtration Area

See table for details.

Filtration efficiency

1.2µm, 2.5µm, 5.0µm, and 10.0µm are 99.9% efficient at the specified pore size. The 0.6µm capsule offers typical retention efficiency of up to 97-100%.

Cartridge extractables

NVR < 3mg per 10" (250mm) capsule

Autoclavable and sanitizable

May be autoclaved for up to 25 cycles at 275°F (135°C), or sanitized using most common cleaning agents.

Maximum Differential Pressure/ Temperature

Forward: 70psid (4.8bar) @ 75°F (24°C)

35psid (2.4bar) @ 140°F (60°C) 20psid (1.4bar) @ 167°F (75°C) Reverse: 30psid (2.1bar) @ 75°F (24°C)

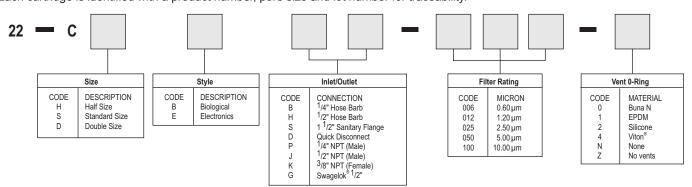
Performance Attributes

FILTER	CAPSULE					TYPICAL AIR FLOW RATE		
RATING	SIZE	ft2	A W cm² gpm 371 0 650 0 836 1 371 0 1021 1 1486 2 743 1 1393 2 1858 3 743 2 1486 4 1950 6 836 2 1486 8 1486 8	gpm/psid	lpm/100mbar	scfm/psid	Nm ³ /hr/100mbar	
	Half	0.4	371	0.4	2.2	3.4	8.4	
0.6µm	Standard	0.7	650	0.8	4.4	5.9	14.6	
	Double	Half 0.8 and and dard 1.5 1 Double 2.0 1 Half 0.8 3 And and dard 1.6 1 Double 1.6 1 Half 0.8 3 And and dard 1.5 1 Double 2.0 1 Half 0.8 3 And and dard 1.6 1 Double 2.1 1 Half 0.9 8 And and dard 1.6 1 Double 2.1 1	836	1.0	5.5	7.6	18.8	
	Half	0.6	371	0.8	4.4	4.5	11.1	
1.2µm	Standard	1.1	1021	1.4	7.7	8.3	20.5	
	Double	1.6	1486	mater gpm/psid 371	11.5	12.0	24.0	
	Half	0.8	743	1.3	7.1	6.2	15.3	
2.5µm	Standard	1.5	1393	2.5	13.7	11.6	28.7	
	Double	2.0	1858	WATER FLOW I cm² gpm/psid lpm 371 0.4 550 0.8 336 1.0 371 0.8 021 1.4 486 2.1 743 1.3 393 2.5 858 3.3 743 2.3 486 4.5 950 6.0	18.1	15.4	38.1	
	Half	0.8	743	2.3	12.6	7.6	18.8	
5µm	Standard	1.6	1486	4.5	24.7	15.2	37.6	
	Double	2.1	1950	6.0	32.9	AIR FLOW RATE scfm/psid Nm³/hr/100r 3.4 8.4 5.9 14.6 7.6 18.8 4.5 11.1 8.3 20.5 12.0 24.0 6.2 15.3 11.6 28.7 15.4 38.1 7.6 18.8	49.5	
	Half	0.9	836	2.8	15.3	8.7	21.4	
10µm	Standard	1.6	1486	5.0	27.5	20.3	50.0	
•	Double	2.1	1950	6.5	35.7	26.6	65.7	

^{*}For fluids with viscosity of 1 cP, and capsules with sanitary fittings.

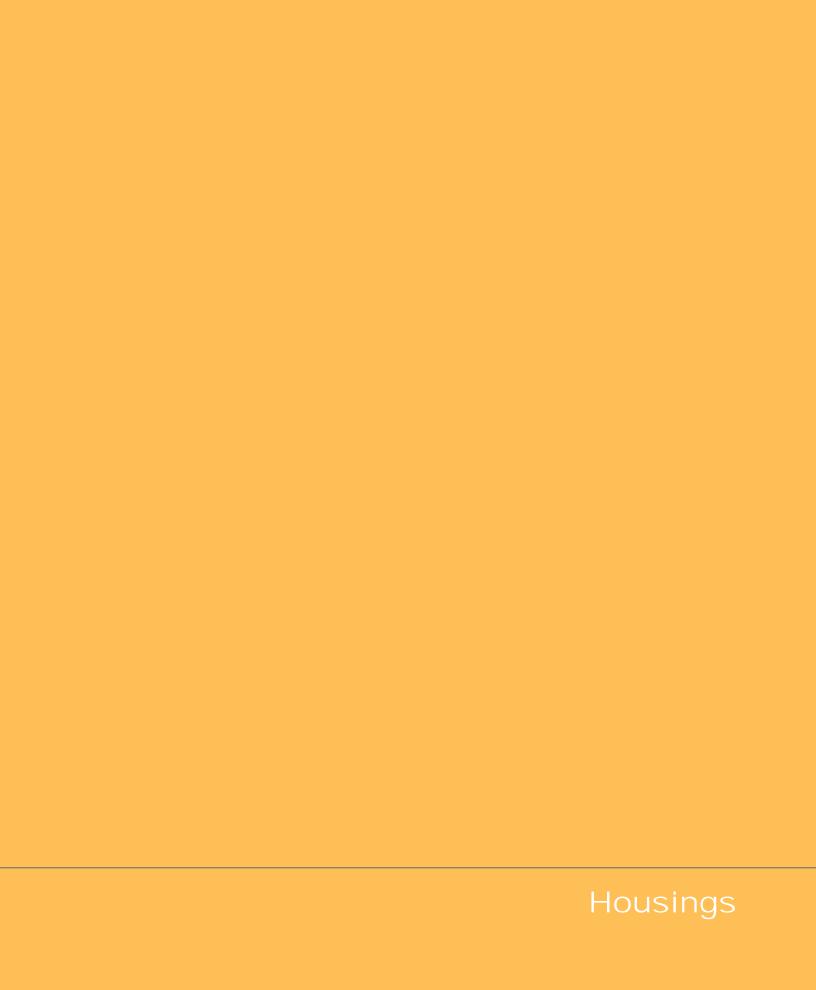
Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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Trufluor[™]

High purity and rugged design for aggressive chemical filtration

The simple, yet rugged design of the TruFluor filtration housing is an excellent solution to any aggressive chemical filtration problem. The two-piece design allows for ease of installation and a positive seal.



Benefits

- High purity PFA construction
- · Also available in PVDF
- Broad chemical compatibility
- · Extremely low extractables
- Available in 4" and 10" versions
- Standard ¼" gauge connections upstream and downstream

Applications

- · High purity acids and bases
- · Aggressive chemical filtration
- · Acid etch and BOE
- · Photomask and Photoresist
 - Chemicals
 - Solvents
 - Developers

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Trufluor[™]

Specifications

Materials of Construction

Head and Bowl : High purity PFA
O-Ring : FEP Encapsulated

Viton¹

NPT Plugs : High purity PFA

Threaded Head

Inserts : PTFE coated 316 Stainless steel

Mounting

Bracket Adapter²: High purity PFA

(10" model only)

Connections

Inlet/Outlet: 3/4" NPT or Butt-Weld

Vent and Drain: 1/4" NPT

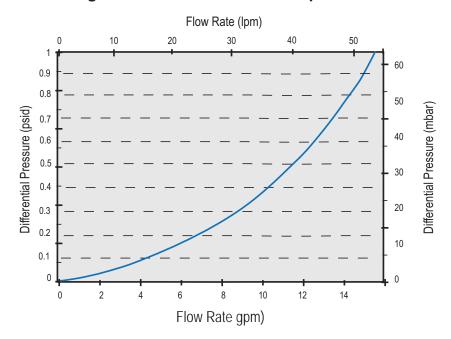
Maximum Operating Specifications

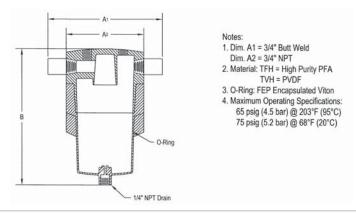
PF4: 65psid (4.5bar) @ 203°F (95°C) 75psid (5.2bar) @ 68°F (20°C)

PVDF 110psig @ 203°F (95°C) 150psig @ 68°F (20°C)

Housing Flow Rate (Liquid): (10" model only)

Housing Differential Pressure vs. Liquid Flow Rate

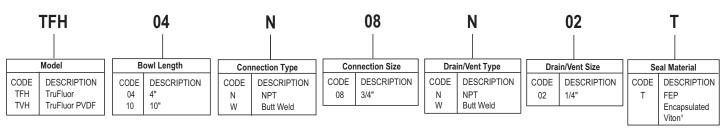




Housing Part Number	Overall Width (A)	Overall Length (B)	Minimum Clearance for Cartridge Removal (C)
TFH04N08N02T	4 7/8" (12.4cm)	7 25/32" (19.8 cm)	6" (15.2 cm)
TFH04W08N02T	7 21/32" (19.4 cm)	7 25/32" (19.8 cm)	6" (15.2 cm)
TFH10N08N02T	4 7/8" (12.4cm)	16" (40.6 cm)	13" (33.0 cm)
TFH10W08N02T	7 21/32" (19.4 cm)	16" (40.6 cm)	13" (33.0 cm)
TVH04N08N02T	4 7/8" (12.4cm)	7 25/32" (19.8 cm)	6" (15.2 cm)
TVH04W08N02T	7 21/32" (19.4 cm)	7 25/32" (19.8 cm)	6" (15.2 cm)
TVH10N08N02T	4 7/8" (12.4cm)	16" (40.6 cm)	13" (33.0 cm)
TVH10W08N02T	7 21/32" (19.4 cm)	16" (40.6 cm)	13" (33.0 cm)

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



- 1 Trademark of E.I. du Pont de Nemours and Co.
- 2 Additional changes apply
- 3 These models are PVDF construction

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Trufluor +™

High purity PFA filter housing

The Trufluor +™ filter housing is designed for maximum chemical resistance and high purity for microelectronics applications. Constructed of PFA (wetted parts) and PVDF (non-wetted parts), this housing is compatible with the most aggressive chemistries. The high-purity materials of construction and cleanroom packaging insure a high level of cleanliness. The housing consists of a stationary bowl and locking ring that provides a positive seal and easy filter replacement. It is compatible with our Fluoroflow® line of all-fluoropolymer cartridges including the large-diameter Fluoroflow®-XL in lengths of 10, 20 and 30 inches.



Benefits

- · Excellent chemical resistance
- High-purity construction
- · Packaged in cleanroom
- · High flow rates
- Compatible with 2.75" and 3.25" diameter cartridges

Applications

- Wet etch and clean (90°C or less)
- Photochemicals
- · DI water

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Trufluor +™

Specifications

Materials of Construction

Head and Bowl High Purity PFA O-Ring FEP Encapsulated

Viton®

Locking Ring PVDF (non-wetted

part)

Connections

Inlet/Outlet 3/4" or 1" Flare

3/4" or 1" Butt-Weld

Vent/Drain 1/4" Flare

> 1/4" Butt-Weld 1/4" NPTF 3/8" Closed 3/8" Flare

Maximum Operating Specifications

50 psig (3.4 bar) at 194°F (90°C) 100 psig (6.9 bar) at 77°F (25°C)

Cartridge Configurations Supported

10"	222/Flat End Cap SS Reinforced 222/Flat End Cap
20"	222/Flat End Cap SS Reinforced 222/Flat End Cap
30"	222/Flat End Cap SS Reinforced 222/Flat End Cap

Dimensional Data

10" Filter

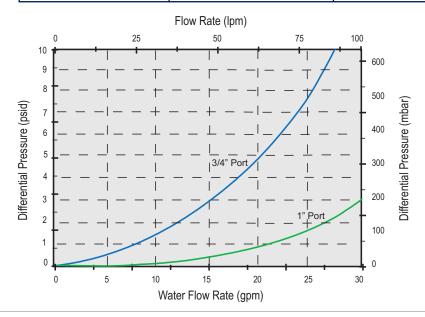
HOUSING STYLE	OVERALL WIDTH	OVERALL LENGTH
3/4" Butt-Weld Pipe	9.0" / 22.9 cm	16.0" / 40.6 cm
3/4" Flare	10.5" / 26.7 cm	19.5" / 49.5 cm
1" Butt-Weld Pipe	9.0" / 22.9 cm	16.0" / 40.6 cm
1" Flare	11.0" / 27.9 cm	19.5" / 49.5

20" Filter

HOUSING STYLE	OVERALL WIDTH	OVERALL LENGTH
3/4" Butt-Weld Pipe	12.0" / 30.5 cm	25.7" / 65.3 cm
3/4" Flare	10.5" / 26.7 cm	29.3" / 74.4 cm
1" Butt-Weld Pipe	9.0" / 22.9 cm	25.7" / 65.3 cm
1" Flare	11.0" / 27.9 cm	29.3" / 74.4

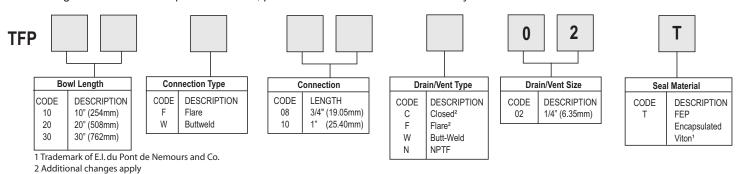
30" Filter

HOUSING STYLE	OVERALL WIDTH	OVERALL LENGTH
3/4" Butt-Weld Pipe 3/4" Flare	12.0" / 30.5 cm 10.5" / 26.7 cm	35.5" / 90.2 cm 39.1" / 99.3 cm
1" Butt-Weld Pipe 1" Flare	9.0" / 22.9 cm 11.0" / 27.9 cm	35.5" / 90.2 cm 39.1" / 99.3



Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



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C - 3055

Fulflo® NP

Natural Polypropylene filter housings for electronicsgrade chemicals

The Fulflo® filter housings are designed for high purity electronics applications. Its natural polypropylene construction provides good chemical compatibility and cleanliness. These housings offer an economical alternative to stainless steel or PFA for less aggressive chemistries. They are available in both 10- and 20-inch lengths and both single- and double-open end designs. A secure head-to-shell O-ring ensures effective sealing while a positive 'stop' design prevents overtightening.



Benefits

- · High-purity construction
- · Versatile design
- Economical
- · Good flow rates

Applications

- Bulk chemical delivery of electronics-grade chemicals
- CMP slurries
- · Plating solutions
- · DI water

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Fulflo® NP

Specifications

Materials of Construction

Vessel100% natural FDA grade polypropylene
Head-to-shell 2-240 O-Ring:
Standard (Industrial Grade): Viton*
Optional (FDA Grade): Buna-N, EPDM, Silicone, FEP encapsulated silicone

Maximum Recommended Operating

Pressure Relief Button O-Ring: Buna-N only

Conditions: Temperature:

125°F (52°C) @ 100 psi (6.9 bar)

Pressure:

150 psi (10.3 bar) @ 75°F (22°C)

Flow Rate:

6 gpm (23 lpm) for 10 in vessel 12 gpm (45 lpm) for 20 in vessel

Recommended Cartridge Dimensions:

NP10:

2-3/8 in to 2-3/4 in O.D. x 1 in I.D.

x 9-5/8 in to 9-13/16 in long

NP20:

2-3/8 in to 2-3/4 in O.D. x 1 in I.D. x 19-7/8 in to 20-1/16 in long

Connection Dimensions:

Inlet/Outlet: 3/4 in (19 mm) NPTF Vent/Drain: 1/4 in (6.4 mm) NPTF

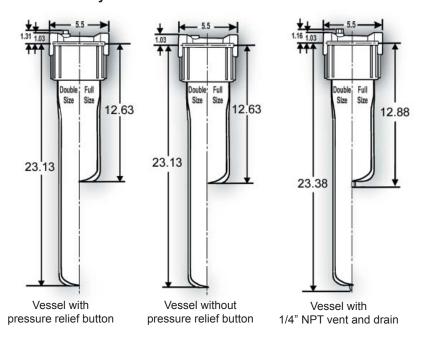
Cartridge Seal Designs:

"TC": Single-Open-End with 222 O-ring receptacle

"DO": Double-Open-End with knife edge seal; also accepts 213 O-ring seal

cartridge (PR code)

Vessel Assembly Dimensions:



Compatible Chemicals (125°F max. temp.)

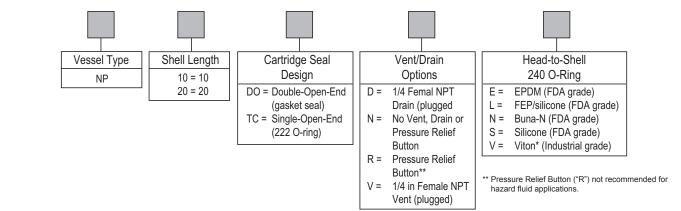
Acetic Acid	50%
Acetone	99.5%
Ammonium Fluoride	40%
Ammonium Hydroxide	10%
Hydrochloric Acid	37%
Hydrofluoric Acid	49%, 52%
Nitric Acid	10%
Phosphoric Acid	85%
Potassium Hydroxide	45%
Sodium Hydroxide	50%
Tetrachloroethylene	99.0%

Standard Vessel Assemblies

NP10-DO-N-V	NP20-DO-N-V
NP10-DO-R-V	NP20-DO-R-V
NP10-D0-DV-V	NP20-DO-DV-V
NP10-TC-N-V	NP20-TC-N-V
NP10-TC-R-V	NP20-TC-R-V
NP10-TC-DV-V	NP20-TC-DV-V

Ordering Information

Each cartridge is identified with a product number, pore size and lot number for traceability.



Specifications are subject to change without notification. *Viton is a registered trademark of E.I. DuPont de Nemours & Co., Inc.

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Filter Recommendation by Application

Application	Char	nicals	Filter I	Family
Application	Cher	ilicais	Primary Choice	Secondary Choice
	Si etch	HF/HNO3/acetic acid	Chemflow	Proflow
Etohina	SiO2 etch	BOE/BHF-HF/NH4F	Clariflow	Fluoroflow
Etching	Si3N4 etch	H3PO4	Fluorocap	
	Al etch	H ₃ PO ₄ /HNO ₃ /acetic acid	Fluoroflow	
	Hydroxy/amine based	NMP, glycol amine, etc.	Chemflow (<60°C), Fluoroflow (>60°C)	Proflow-E (<60°C) Fluoroflow (>60°C)
Residue Removal	Glycol/NH4F based	Glycol, NH4F	Chemflow (<60°C), Fluoroflow (>60°C)	Proflow-E (<60°C) Fluoroflow (>60°C)
	DMSO/amine based	DMSO/amine, EL/2 pentamone	Proflow (<60°C), Fluoroflow (>60°C)	Chemflow-E (<60°C) Fluoroflow (>60°C)
	Pirahha	H2SO4/H2O2	Fluorocap	Fluoroflow XF
Cleaning	SC1	NH4OH/H2O2/H2O	Fluoroflow	
	SC2	HCI/H2O2/H2O	Fluoroflow	
	Cu, Ni, Au, etc.	Metal compound/acid or base/buffer	Clariflow (<60°C), Fluoroflow (>60°C)	Polyflow M (<60°C) Fluoroflow (>60°C)
	Photoresist	Photo sensitive agent/ polymer resin	Polyflow M	Chemflow
Photochemical			Chemflow PE	
Filtration	Developing		Fluoroflow	
			Proflow	
CMP	Oxide		Polyflow G	
CIVIP	Copper		Polyflow G	
DI	Rinsing	H ₂ O	Clariflow (<60°C), Fluoroflow (>60°C)	
Ozonatde DI	Rinsing	H2O/O3	Fluoroflow	

SELECT Pleating Technology

Bath recovery rate is related to a filter's flow capacity. However, space availability in process baths is limited, thus there is always a constant challenge to increase the surface area and the flow capacity of the filter without increasing its size.

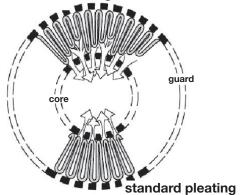
Our revolutionary SELECT pleating utilizes an innovative pleat-design that not only increases the effective filtration area, but also greatly increases the flow-rate as compared to conventional types of pleating. SELECT pleating effectively offers up to 80% more filtration area, which translates into twice the flow capacity. Bath recovery can thus be significantly improved and costs lowered.

Ultraclean Leads the Microelectronics Industry in Cleanliness

To improve product quality and yield, our R&D and design teams have successfully developed the revolutionary Ultraclean cleaning process. This proprietary process is applied to electronics grade products to provide a total metals extractables level of <5ppb.

Ultraclean's low levels of metals extractables provide users with a highly consistent manufacturing process – and thus very low product reject rates.

SELECT-Pleating



Chemical Compatibility Chart

Microelectronics Industry

This chemical compatibility chart uses a rating system: A, B, C and F (most compatible to least) and is an easy way of rating a filter based solely on its chemical compatibility. However, all chemical compatibility guides are intended as general reference documents. By their nature, they cannot address the wide ranges of process parameters and their interactions. These include variations in temperature, pressure, chemical concentration, solid or liquid phase, pH level, and solubility. As each of these parameters is changed, so a material's resistance to chemical attack can be affected.

Due to this variability, we recommend that users contact our Technical Services team in order to confirm the suitability and chemical resistance of a proposed filter material for each application. Our Technical Services team will undertake a compatibility evaluation and provide a product recommendation.

recommendation.		FILTERS					O-RINGS					HOUSINGS				
A = Recommended B = Conditionally recommended C = Non-critical applications at ambient F = Do not use	Fluoroflow®	FluoroCap™	Proflow II TM	Chemflow PE®	Polyflow [®] Membrane	Polyflow®	Clariflow®	Chemrez®	Teflon® Encapsulated Viton®	Viton®	EPR	Silicone	Buna	PFA	Stainless Steel	PVC
Acetic Acid (5-80%)	Α	Α	С	С	Α	Α	С	Α	Α	Α	Α	F	В	Α	Α	Α
Acetic Acid Glacial	Α	Α	В	С	В	В	С	Α	Α	F	В	F	В	Α	С	В
Acetone (Dimethylketone)	Α	Α	Α	С	Α	Α	F	Α	Α	F	Α	F	F	Α	Α	А
Ammonium Fluoride	Α	Α	В	Α	В	В	Α	Α	Α	Α	Α	F	В	Α	F	В
Ammonium Hydroxide	Α	Α	Α	С	Α	Α	Α	Α	Α	В	Α	Α	В	Α	С	Α
Aqua Regia	Α	Α	F	F	F	F	F	Α	Α	F	F	F	F	Α	F	F
BOE; NH4F:HF	Α	Α	Α	В	Α	В	Α	Α	Α	Α	F	F	F	Α	F	А
Carbon Tetrachloride	Α	Α	F	F	F	F	F	Α	Α	Α	F	Α	F	Α	В	F
Citric Acid	Α	Α	Α	Α	Α	Α	В	Α	Α	Α	Α	Α	F	Α	Α	С
Chrom Phos; (32:1:0.1) H2O:H3PO4:CRO2	Α	Α	В	В	С	С	F	Α	Α	С	F	F	F	Α	С	F
Coating Aquator AZ	Α	Α	Α	В	С	С	F	Α	Α	F	С	F	F	Α	Α	В
Copper Sulfate	Α	Α	Α	С	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α
Dimethyl Sulfoxide (DMSO)	Α	Α	Α	В	Α	Α	F	Α	Α	F	Α	F	F	Α	Α	F
EGMEA	Α	Α	В	В	В	С	F	Α	Α	F	F	F	F	Α	В	F
EKC (Strip) Pyrollidone, n-methyl (NMP) to 40°C	Α	Α	С	С	С	С	F	Α	Α	F	В	F	F	Α	Α	В
EKC (Strip) Pyrollidone, n-methyl (NMP) 40-150°C	Α	Α	F	F	F	F	F	Α	Α	F	F	F	F	Α	Α	F
Ethanol	Α	Α	Α	Α	Α	Α	Α	Α	Α	В	Α	Α	Α	Α	Α	Α
Freon TF	Α	Α	В	С	С	С	F	Α	Α	В	F	F	F	Α	Α	С
Hexamethyldisilazane (HMDS)	Α	Α	В	С	В	С	F	Α	Α	F	F	F	F	Α	С	F
Hydrochloric Acid (5-30%)	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α	F	В	Α	F	Α
Hydrofluoric Acid (10-49%)	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α	С	F	С	Α	Α	Α
Hydrofluoric Acid 50%	Α	Α	Α	В	F	F	В	Α	Α	Α	F	F	F	Α	Α	F
Hyrdofluoric Acid (conc.) cold	Α	Α	С	С	Α	Α	F	Α	Α	Α	F	F	F	Α	В	А
Hydrogen Peroxide (3-10%)	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α	В	Α	В	Α	Α	Α
Hyrdogen Peroxide (11-30%)	Α	Α	Α	Α	Α	Α	В	Α	Α	Α	В	Α	F	Α	Α	Α
Hydrogen Peroxide (31-90%)	Α	Α	Α	В	Α	Α	F	Α	Α	Α	F	В	F	Α	Α	Α
Isopropyl Alcohol (IPA)	Α	Α	Α	Α	Α	Α	Α	Α	Α	Α	В	Α	В	Α	Α	Α
Methanol	Α	Α	Α	Α	Α	Α	В	Α	Α	С	В	В	В	Α	Α	Α
Methylene Chloride	Α	Α	В	С	F	F	F	Α	Α	В	F	F	F	Α	Α	F
Methyl Ethyl Ketone (MEK)	Α	Α	В	С	F	F	F	Α	Α	F	Α	F	F	Α	Α	F
Mixed Acid Etch; (HNO3<20%:HF:CH3:CO2H)	Α	Α	С	F	С	С	F	Α	Α	С	F	F	F	Α	В	F
Negative Resist	Α	Α	С	С	F	F	F	Α	Α	Α	F	F	F	Α	Α	F
Nitric Acid (10-35%)	Α	Α	Α	F	Α	Α	В	Α	Α	Α	В	Α	F	Α	Α	Α
Nitric Acid (50-70%)	Α	Α	F	F	F	F	F	Α	Α	Α	F	F	F	Α	Α	F
Nitric Acid (conc.)	Α	Α	F	F	F	F	F	Α	Α	В	F	Α	F	Α	С	F
NOE; NH4F:H20: Ethylene Glycol/Surfactant	Α	Α	Α	Α	С	С	Α	Α	Α	С	С	F	С	Α	F	С
P-Etch; (92:5:3) DI H20:HF:HNO3	Α	Α	В	F	С	С	F	Α	Α	В	F	F	F	Α	В	С

Chemical Compatibility Chart

Microelectronics Industry

A = Recommended B = Conditionally re		FILTERS							O-RINGS						HOUSINGS		
Potitionam Ethier A A C C C C C C A A B F F B A A F F F P Potitionam Ethier Potitionam Ethier A A F F F F F F F F F F F F F F A F	B = Conditionally recommended C = Non-critical applications at ambient	Fluoroflow®	FluoroCap™	Proflow II™	Chemflow PE®	Polyflow [®] Membrane	Polyflow®	Clariflow®	Chemrez®	Teflon® Encapsulated Viton®	Viton®	EPR	Silicone	Buna	PFA	Stainless Steel	PVC
Prinche (HSSOEHDO)	PEGMEA	Α	Α	В	Α	С	С	F	Α	Α	F	F	F	F	Α	В	F
Prosphoric Acid (10-19%) to 65°C A A A A A A C C A A A A B B B A A A A A	Petroleum Ether	Α	Α	С	С	С	С	С	Α	Α	В	F	F	В	Α	Α	F
Phosphoric Accid (20 50%) to 65°C A A A F C A A F A A A B F F A A A A F Phosphoric Accid (20 1-10%) to 65°C A A A F C A A F A A B F F A A B F F A A F Phosphoric Accid (20 1-10%) to 65°C A A A F F A A F A A F A A B F F A A B F F A A F F A A F F A A F F F A A F F F A A F F F A A F F F A A F F F F A A F F F F F A A A F F A A F F F F F A A A F F A F F F F A A F F F F F A A F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F F A A F F F F F A A F F F F F A A F F F F F	Piranha; (H2SO4:H2O2)	Α	Α	F	F	F	F	F	Α	Α	F	F	F	F	Α	F	F
Phosphoric Acid (G1-80%) to 65°C	Phosphoric Acid (10-19%) to 65°C	Α	Α	Α	Α	Α	Α	С	Α	Α	Α	Α	В	В	Α	Α	Α
Phosphoric Acid (conc.) to 65°C A A A F A F F A A F F A A B F F A A A F F A A B F F A A A F F A A A F F A A A F F A A A F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A F F F F F A A A C Positive Resist A2 4330 A A A B C C F A A F B F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F C F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A A C F F A A F F A F F A A C C Positive Resist Shipley S 1800 A A A B C C F A A F A F F A F F A A C F F A A F F A F F A A C C Positive Resist Shipley S 1800 A A A B C C F A A F A F F F A A C F F A A F F A F F A A C C Positive Resist Shipley S 1800 A A A B B A A A A B A A A A B A B B A A B B B A A A A A B B A B B B A A A A A B B A A B B A A B B A A A A A B B A B B B A A A A A B B A A B B A A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A B B A B B B A A A A A A B B A B B B A A A A A A B B A B B B A A A A A A B B A B B B A	Phosphoric Acid (20-50%) to 65°C	Α	Α	Α	Α	Α	Α	С	Α	Α	Α	Α	F	F	Α	Α	Α
Phosphoric Acid d6-150°C	Phosphoric Acid (51-80%) to 65°C	Α	Α	F	С	Α	Α	F	Α	Α	Α	В	F	F	Α	Α	F
Phissphoric Acid d5-150°C		А	Α	А	F	А		F			Α	В	F	F	Α	Α	
PMMA Developer		Α	Α	F	F			F			F	F	F	F	Α		
PMMA Rinse				А	В	С		F			F	Α	F	F	Α	Α	
Positive Resist AZ 4330	PMMA Rinse	Α	A	Α	В	С	С	F	Α	Α	F	В	F	F	Α	Α	С
Positive Resist																	
Positive Resist, Shipley S 1800								F			F		F	F			
Positive Resist, Shipley S 1400								F			F						
Positive Resist, Shipley System 8 A A A B C C F A A F A F F A A C Positive Resist, AZ 1300 series A A A B C C F A A F A F F A A C Positive Resist, AZ 1300 series A A A B C C F A A F A F F A A C Positive Resist, AZ 5200 series A A A B C C F A A F A F F A A C C Positive Resist, AZ 5200 series A A A B A B C C F A A F A F F A A C C Positive Resist, AZ 5200 series A A A B A A B A A B A B B A A B B A A B B A A B B A A B B A A A A A B B A A B B A A A A A B B A A B B A A A A A A B B A A B B A A A A A A B B A A B B A A A A A A B B A A B B A A A A A A A A A A A A A A A A B B A A B B A A A B B A A B B A A A A A A A B B A A B B A A A B B A A A B B A A B B B A A A A A A B B A B B B A A A B B B B A A A B B B B B A A A B	. ,							F			F		F	F			
Positive Resist, AZ 1300 series	. ,	Α	A	Α	В	С	С	F	Α	Α	F	Α	F	F	Α	Α	С
Positive Resist, AZ 5200 Series A A A B C C F A A F A F F A A C Potassium Hydroxide 10% A A A B A B A A B A B A A B B A A B B A B B A A A A A B B A A B B A A A A A B B A A A A A B B A A A A A B B A A A A A B B A A A A A A B B A A A A A B B A A A A A A B B A A A A A A B B A A A A A A B B A A A A A A A B B A A A A A A A B B A A A B B A A B B B A A A B B B B A A A B B B B B A A A A A B B B B B A A A B		Α	Α	Α	В	С	С	F	Α	Α	F	Α	F	F	Α	Α	С
Potassium Hydroxide 10%					В			F			F		F	F			
Potassium Hydroxide 30%																	
PRS-3000 (Strip) see Pyrallidone Pyrallidone, n-methyl (NMP) to 40°C A A C C C F A A F F A A B F F A A F F F A A F F F F A A F F F A A F F F A A F F F A A F F F A A F F F A A F F F A A F F F A A F F F A A F F F A A F F F A A F F F F A A F F F A A F F F A A C C C C C C C C <td< td=""><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td></td<>																	
RCA Etch; (75:15:5:5); H3PO4:CH3CO2H:HNO3:DI H2O	PRS-3000 (Strip) see Pyrallidone													F			
SC1: (RCA Clean) NH40H:H2O2:DI H2O A A C C F F C A A C C F F C A A C F F F F A C C SC2: HCI:H2O2:DI H2O A A F C F A	Pyrallidone, n-methyl (NMP) 40-150°C	Α	Α	F	F	F	F	F	Α	Α	F	F	F	F	Α	Α	F
SC1: (RCA Clean) NH40H:H2O2:DI H2O A A C C F F C A A C C F F C A A C F F F F A C C SC2: HCI:H2O2:DI H2O A A F C F A C C C Scolum Hydroxide (20-40%) A	, , , ,			В			F	F			В		F				
SC2; HCI:H2O2:DI H2O A A F C F F C A A C F F F A C C Sodium Hydroxide 5% A A A B A	· '							С					F				
Sodium Hydroxide 5% A A A B A			Α	F	С	F	F	С			С	F	F	F	Α	С	С
Sodium Hydroxide (20-40%) A A A B B A A F A F C A A A Sulfuric Acid (5-25%) to 65°C A F F F F F F F F F F F F	Sodium Hydroxide 5%	Α	Α	Α	В	Α	Α	Α	Α		F	Α	С	Α	Α	Α	Α
Sulfuric Acid (5-25%) to 65°C A															-		
Sulfuric Acid (50-60%) to 65°C A F F F F A A A F F F F A <th< td=""><td>, , ,</td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td><td></td></th<>	, , ,																
Sulfuric Acid (75-96%) to 65°C A A A A A A F F F F A B A Sulfuric Acid (conc.) to 65°C A A F C F F F A A C F F F A F F F F A A F F F F A A F A																	
Sulfuric Acid (conc.) to 65°C A A F C F																	
Sulfuric Acid 65-150°C A A F	` '														-		
Tetramethyl Ammonium Hydroxide (TMAH 5%) A A A B B B F A A C C C F A B C Water, Deionized to 65°C A F F F A A A A F A A A A A A A F A A <td></td>																	
Water, Deionized to 65°C A <td></td> <td></td> <td></td> <td></td> <td></td> <td>В</td> <td></td> <td></td> <td></td> <td></td> <td></td> <td></td> <td>С</td> <td></td> <td>-</td> <td></td> <td></td>						В							С		-		
Water, Deionized 65-95°C A A F F F F F F F F F A B C Water, Ozonated A A F C F F F A A A A F A A F A A F A A F A A F A A F A A F A A F A A F A A F A A F A A F A A F A A F A A F A A F A A A A F A A A A A F A	Water, Deionized to 65°C		А	А	Α	Α	А	Α	Α	А	Α	Α	Α	Α	Α	В	С
Water, Ozonated A A F C F F A A A A A F A A F	Water, Deionized 65-95°C	Α	Α	F	F	F	F	F	Α	Α	F	F	F	F	Α	В	С
				F	С	F	F	F			Α	Α	Α	F			F
	Xylene (Xylol)	Α	Α	F	F	F	F	F	Α	Α	Α	F	F	F	Α	Α	F



FAILURE OR IMPROPER SELECTION OR IMPROPER USE OF THE PRODUCTS AND/OR SYSTEMS DESCRIBED HEREIN OR RELATED ITEMS CAN CAUSE DEATH, PERSONAL INJURY AND PROPERTY DAMAGE.

This document and other information from Parker Hannifin Corporation, its subsidiaries and authorized distributors provide product and/or system options for further investigation by users having technical expertise. It is important that you analyze all aspects of your application and review the information concerning the product or system in the current product catalog. Due to the variety of operating conditions and applications for these products or systems, the user, through its own analysis and testing, is solely responsible for making the final selection for the products and systems and assuring that all performance, safety and warning requirements of the application are met.

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